

Integrating Resonant Structures with IR Detectors

Org. 05265 Applied Photonics Microsystems Research and Technology Seminar

Michael Goldflam



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Collaborators



Smart Sensors Technology Grand Challenge

PI: David Peters
PM: Reno Sanchez

Nanoantenna Enhanced Detectors

Evan Anderson	Jin Kim
Salvatore Campione	John Klem
Wesley Coon	S. Parameswaran
Paul Davids	Eric Shaner
Torben Fortune	Michael Sinclair
Sam Hawkins	Anna Tauke-Pedretti
Clark Kadlec	Larry Warne
Emil Kadlec	Joel Wendt
Gordon Keeler	Michael Wood

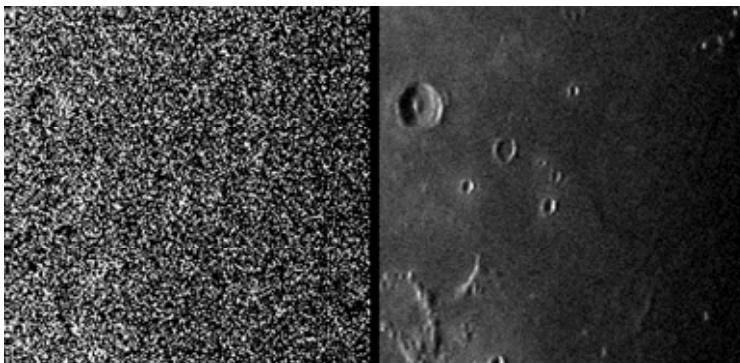
Tunable Filters

Thomas Beechem
Stephen Howell
Anthony McDonald
Isaac Ruiz
Joel Wendt

The Goal

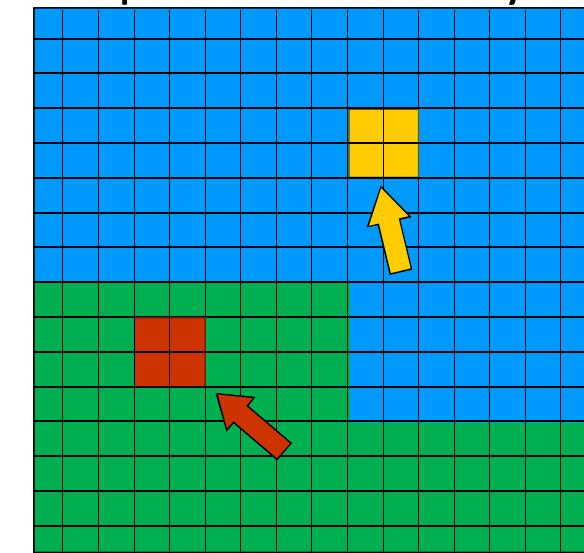
Develop the foundation for a new infrared detector that will lead to an order of magnitude improvement in noise and real-time spectrally tunable pixels.

Noise Reduction



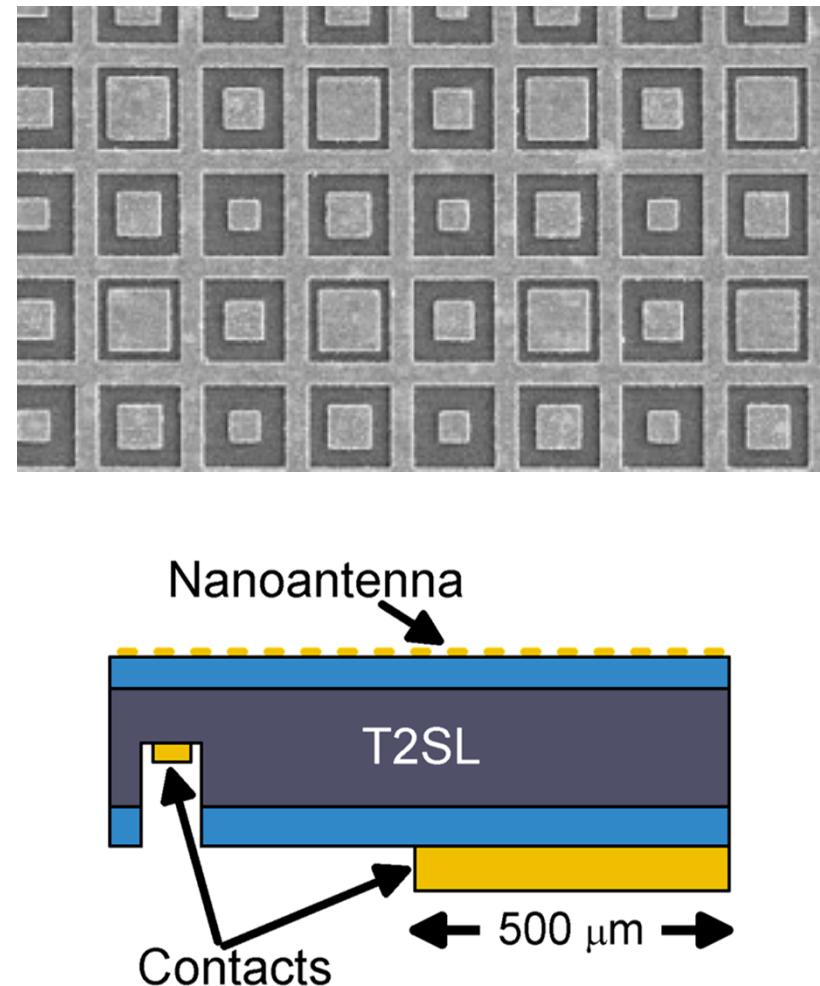
To achieve a radically improved sensor both new architectures and materials must be investigated.

Pixel-Level Active Spectral Tunability

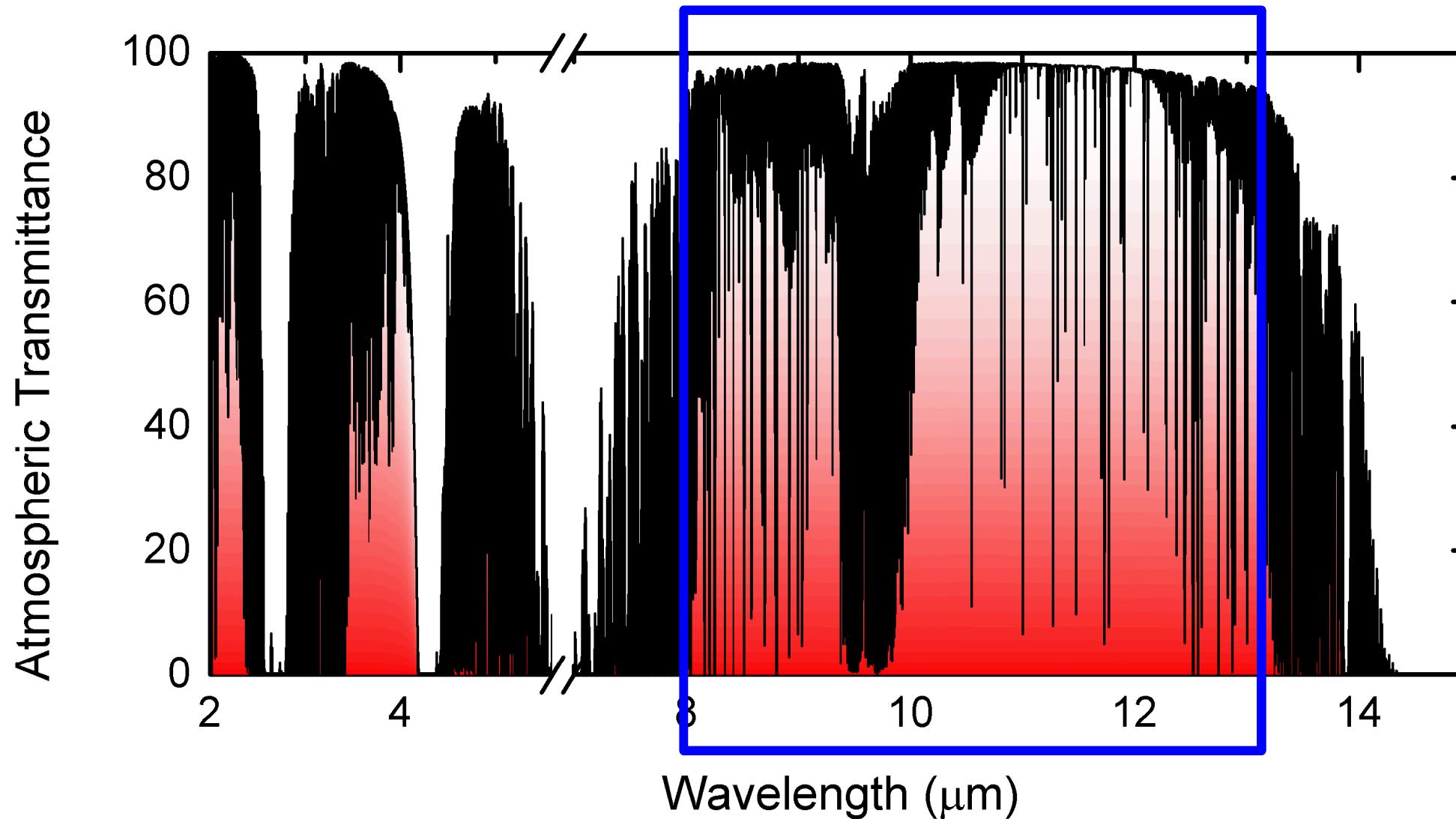


Outline

- Resonantly Enhance IR Detectors
 - Type-II Superlattices
 - Metallic nanostructures
- Tunable IR Filters
 - Graphene
 - Reflectance-mode Filter
- Summary



Infrared Detection

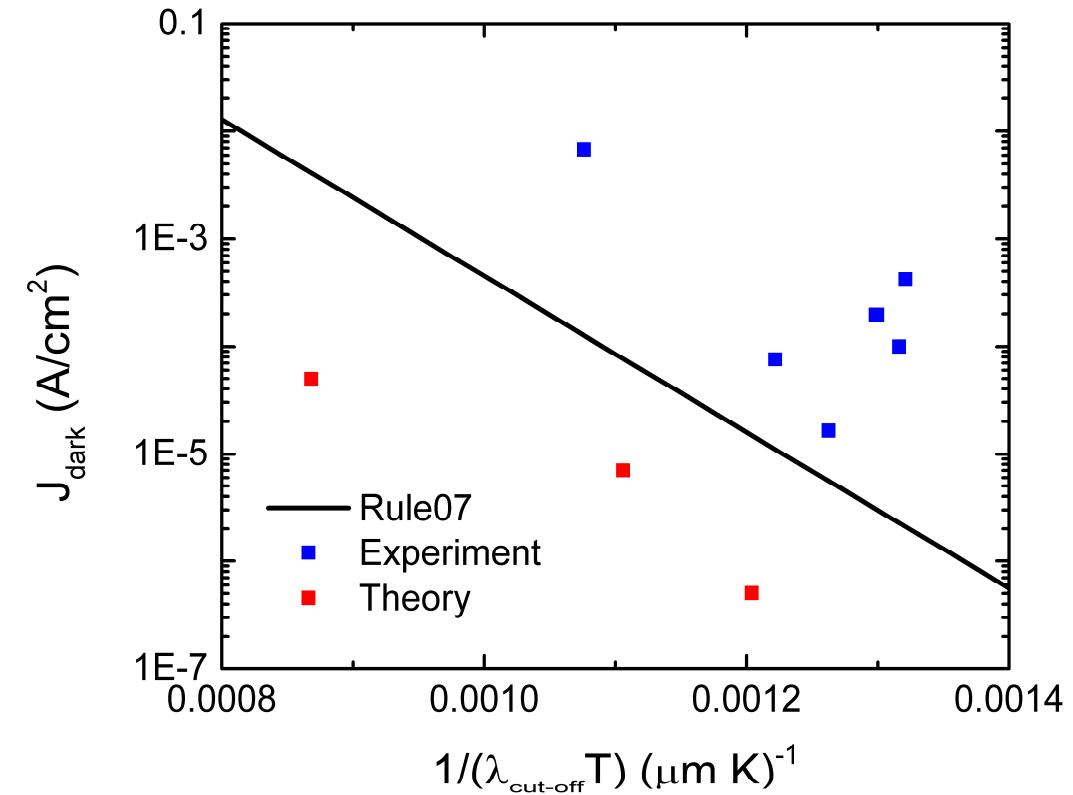
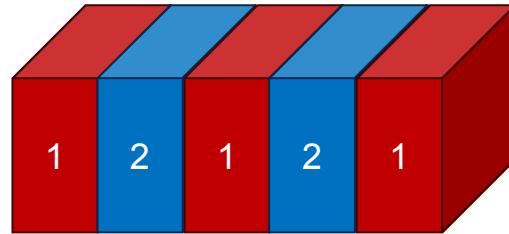


Lord, S. D., 1992, NASA Technical Memorandum 103957, Gemini Observatory

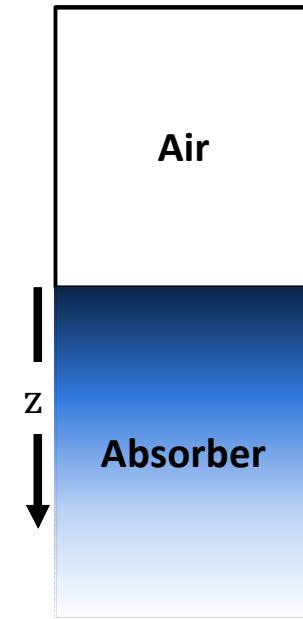
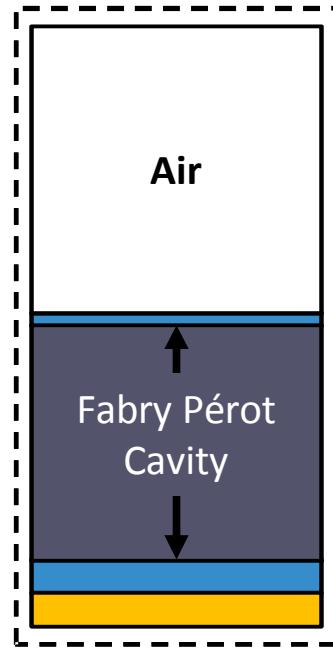
Type-II Superlattices

- InAs/(In)GaSb
- **InAs/InAsSb**
- InGaAs/InAsSb

- Bandgap controlled by layer thickness
- Uniform material across wafer
- Predicted lower predicted dark current than MCT.
- Lower absorption coefficient than MCT



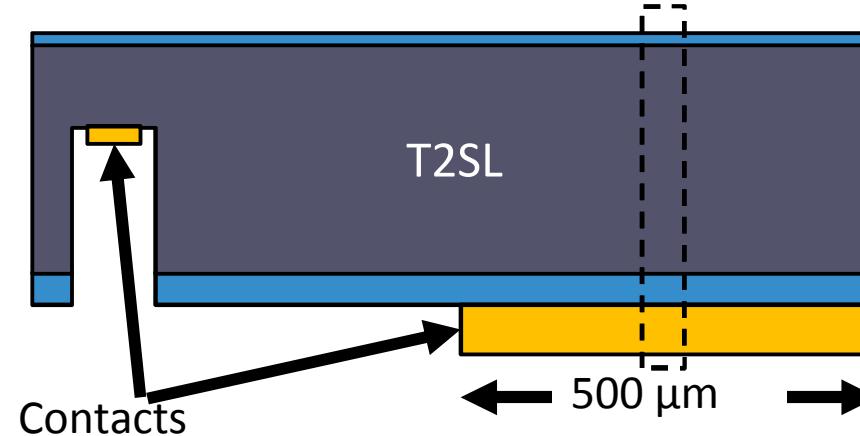
Detector structure



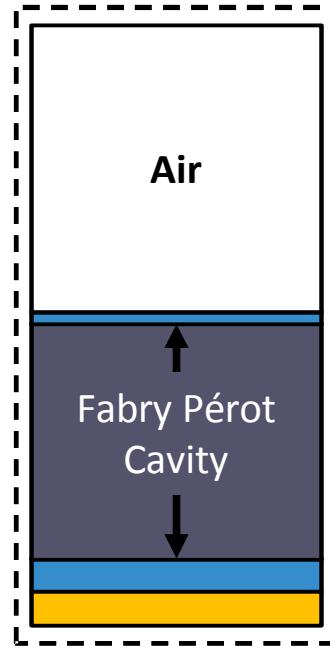
$$\text{Absorption} \propto 1 - e^{-\alpha z}$$

$$J_{\text{diff}} \propto W$$

- Thick structures absorb more but have higher dark current.
- Enhance field in detector using resonant structures → increase QE.
- Important in low background applications.
- Enable higher operating temperature.

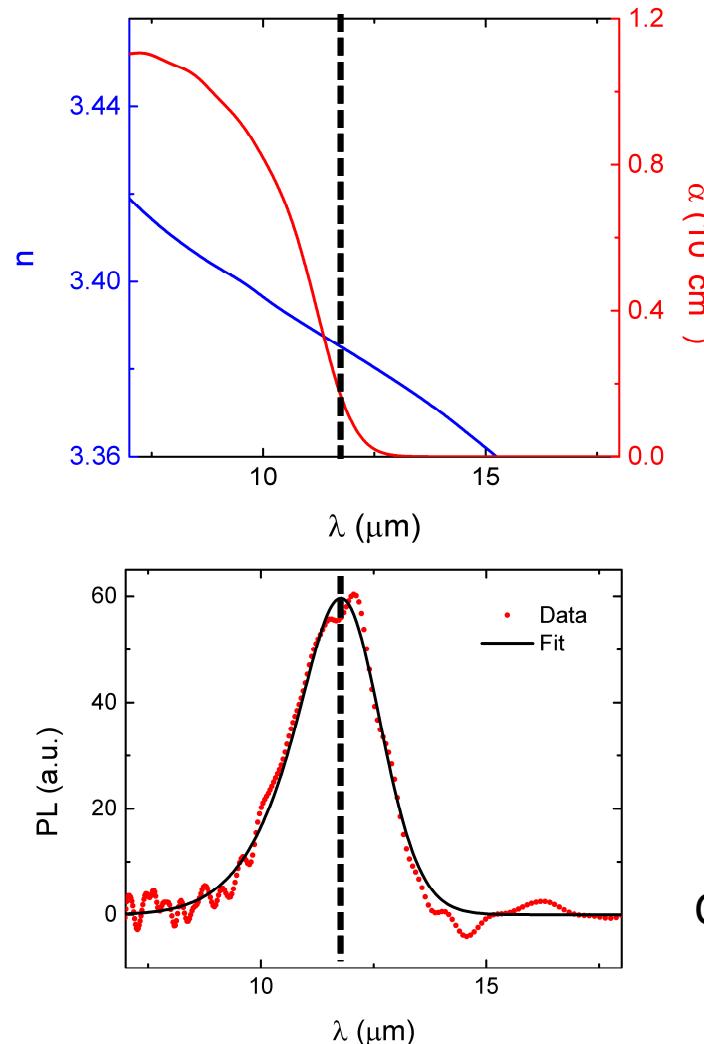


Detector structure

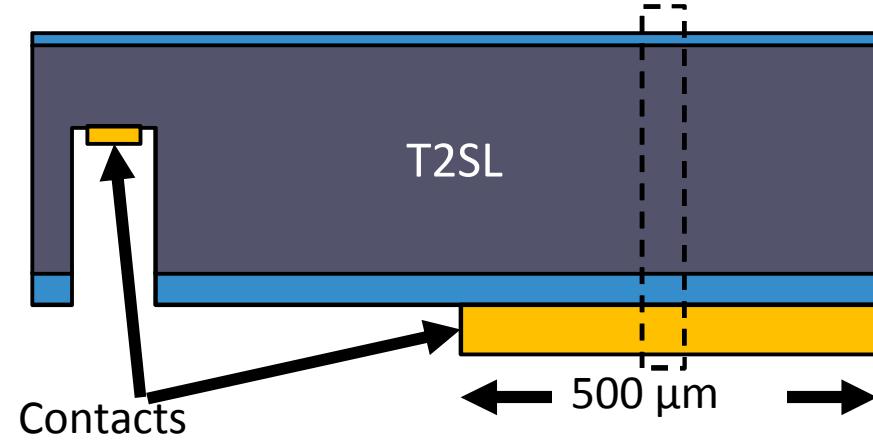


$$\lambda_{res}^{FP} = \frac{4nt}{2m - 1}$$

$t \sim 2 \text{ } \mu\text{m}$

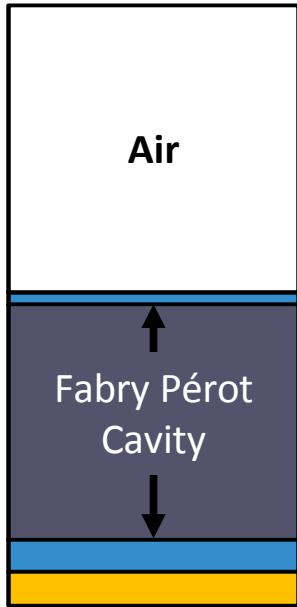


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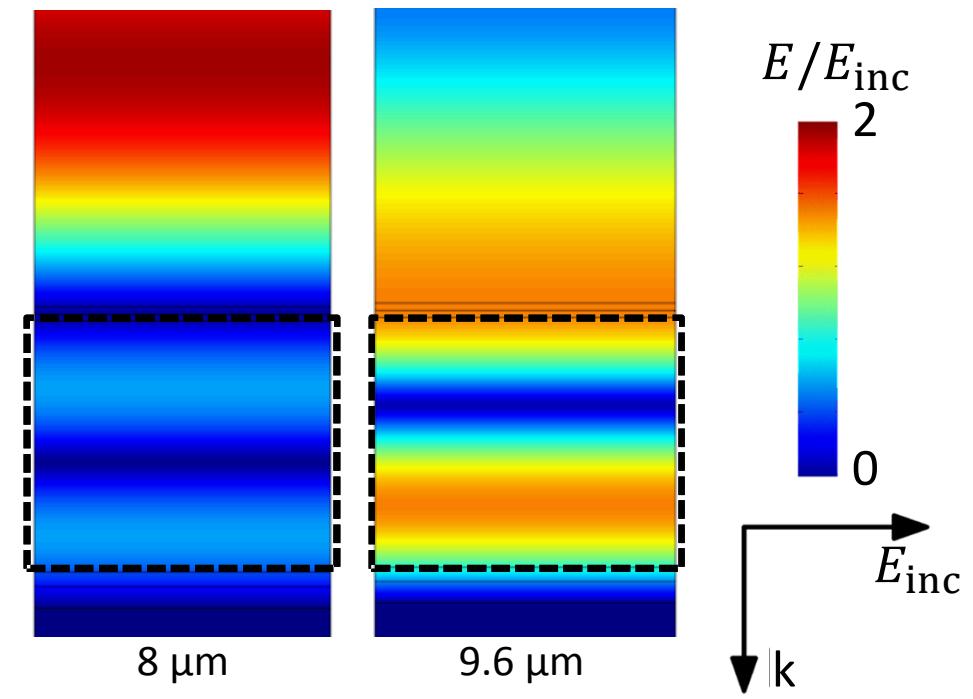
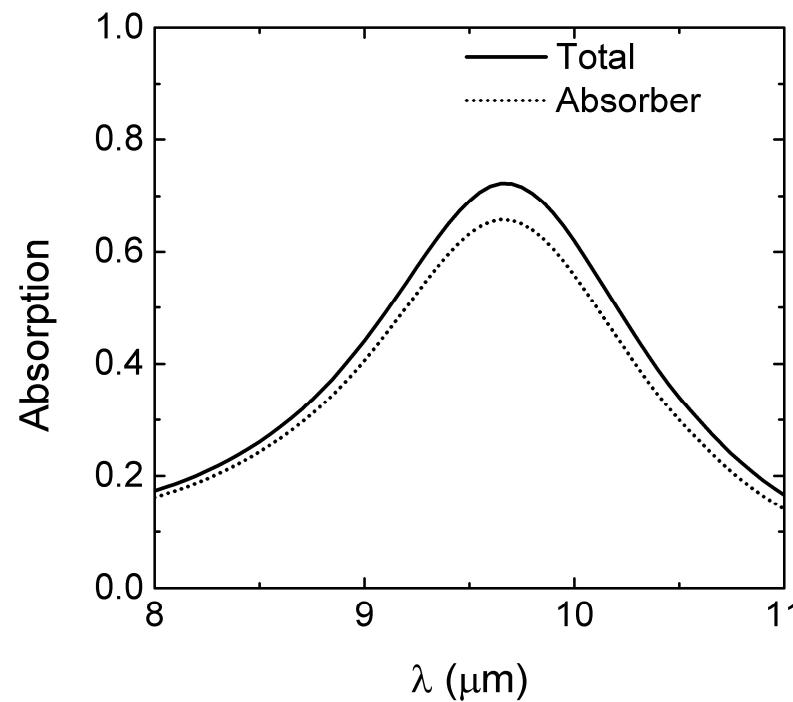
M. D. Goldflam, D. W. Peters et al., Appl. Phys. Lett. 109 (25), 251103 (2016).

Resonant detector: Fabry-Pérot

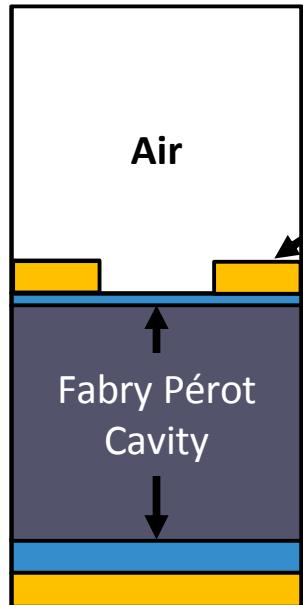


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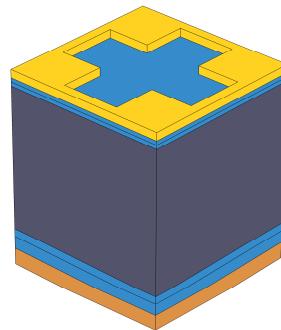
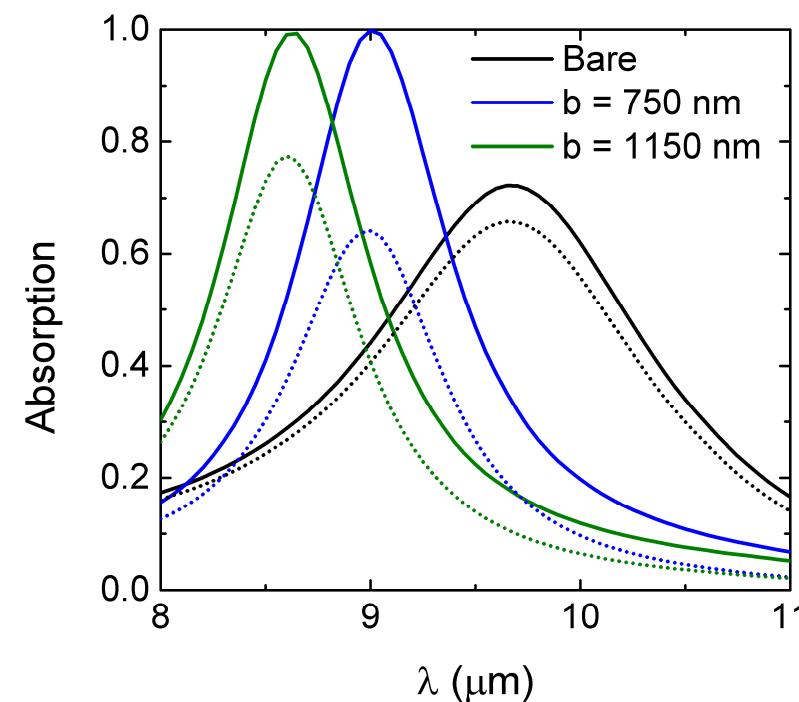
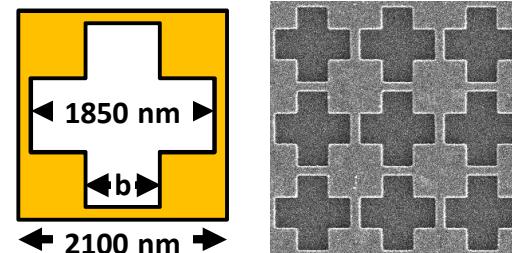
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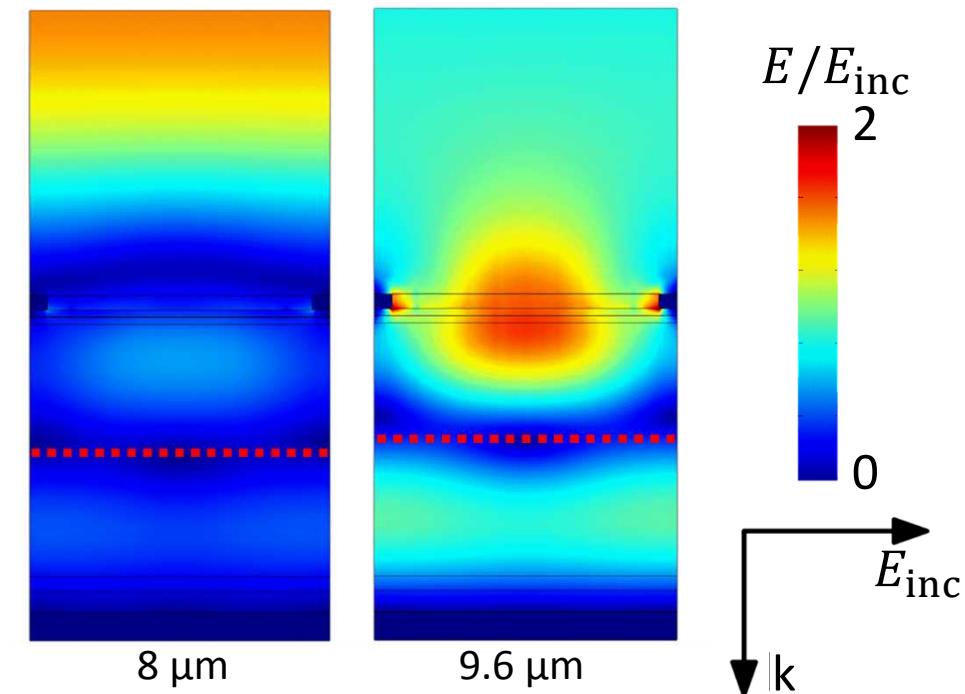
Coupled Resonances



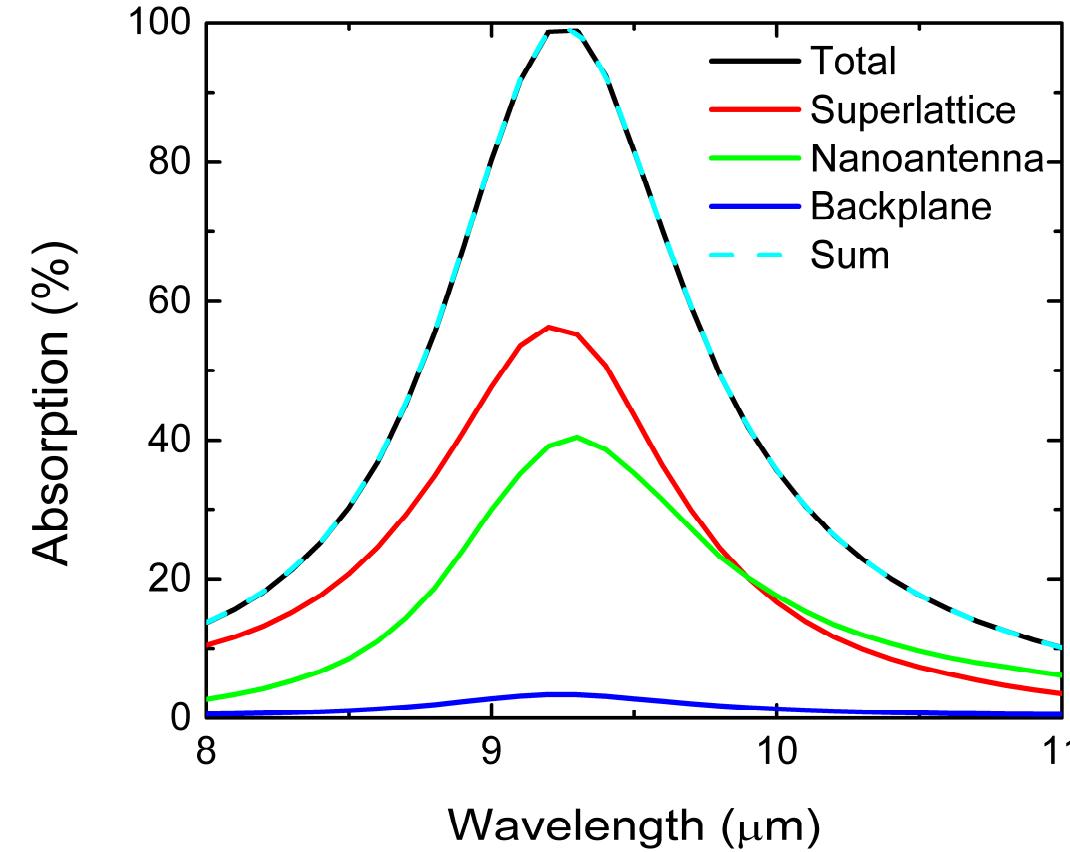
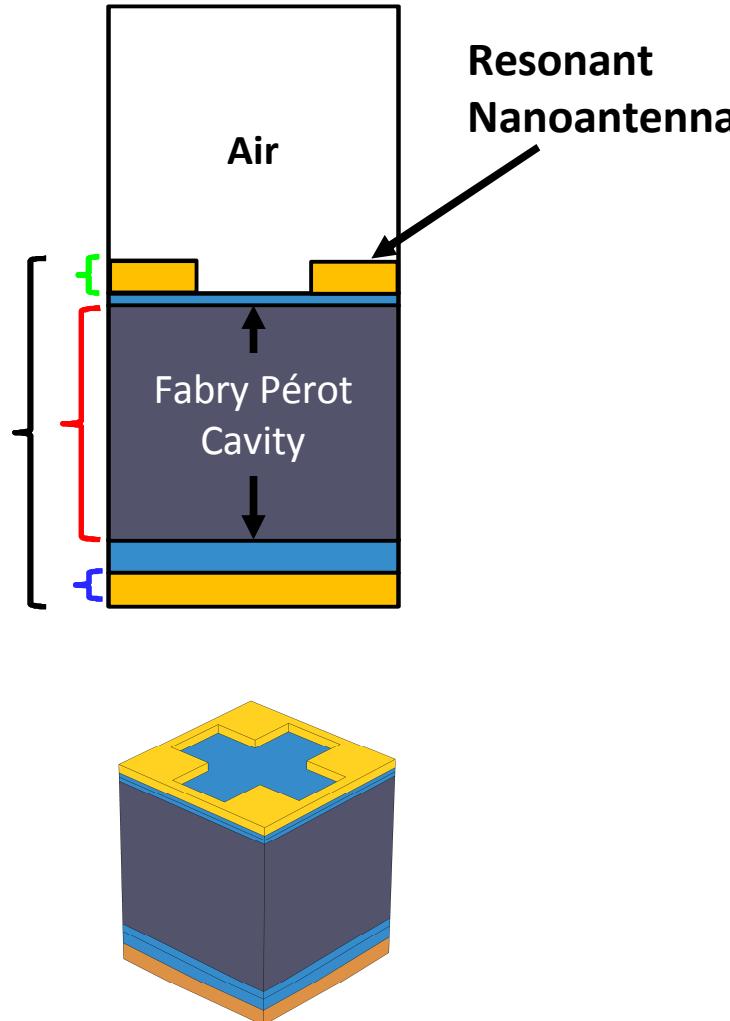
Resonant
Nanoantenna



- Employ two coupled resonances: Fabry-Pérot cavity with metal nanoresonator.
- Variable response in fixed detector through variation of nanoantenna only.

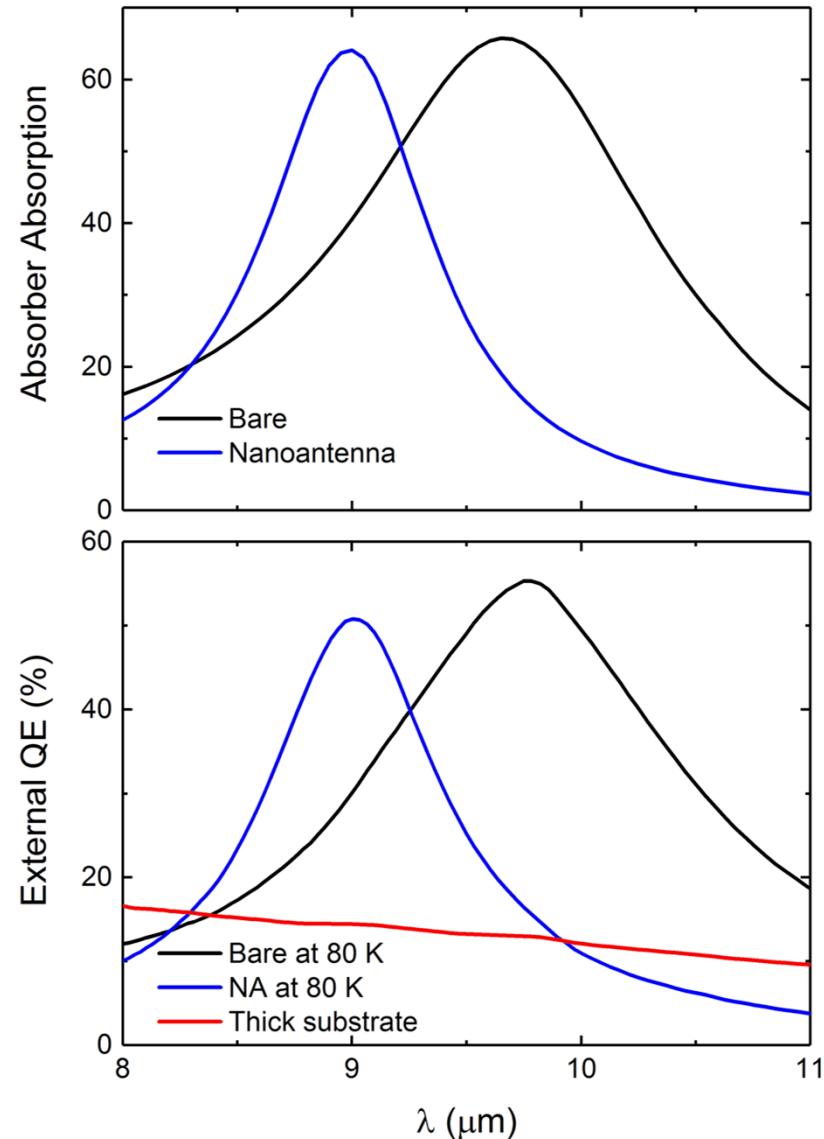
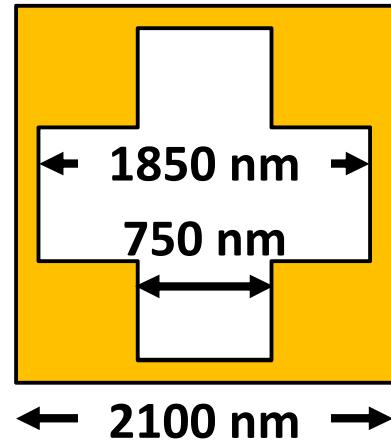
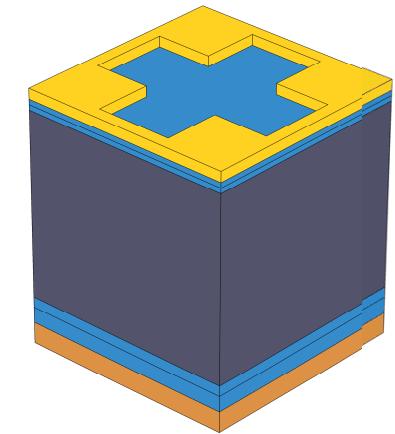


Loss Mechanisms

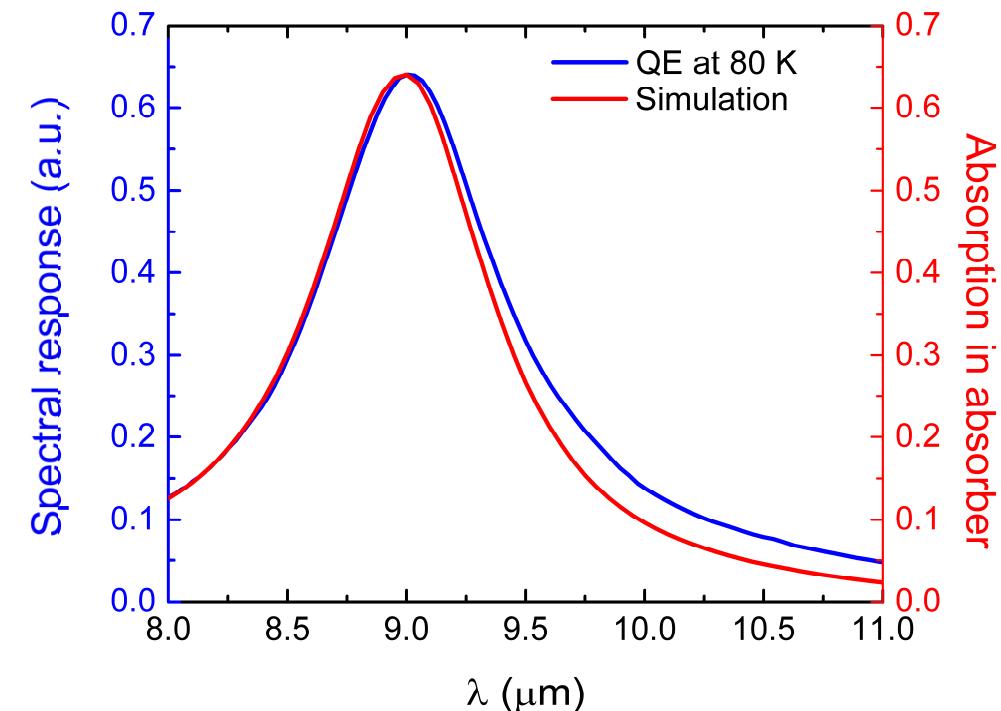


Majority of “lost” absorption is in the nanoantenna

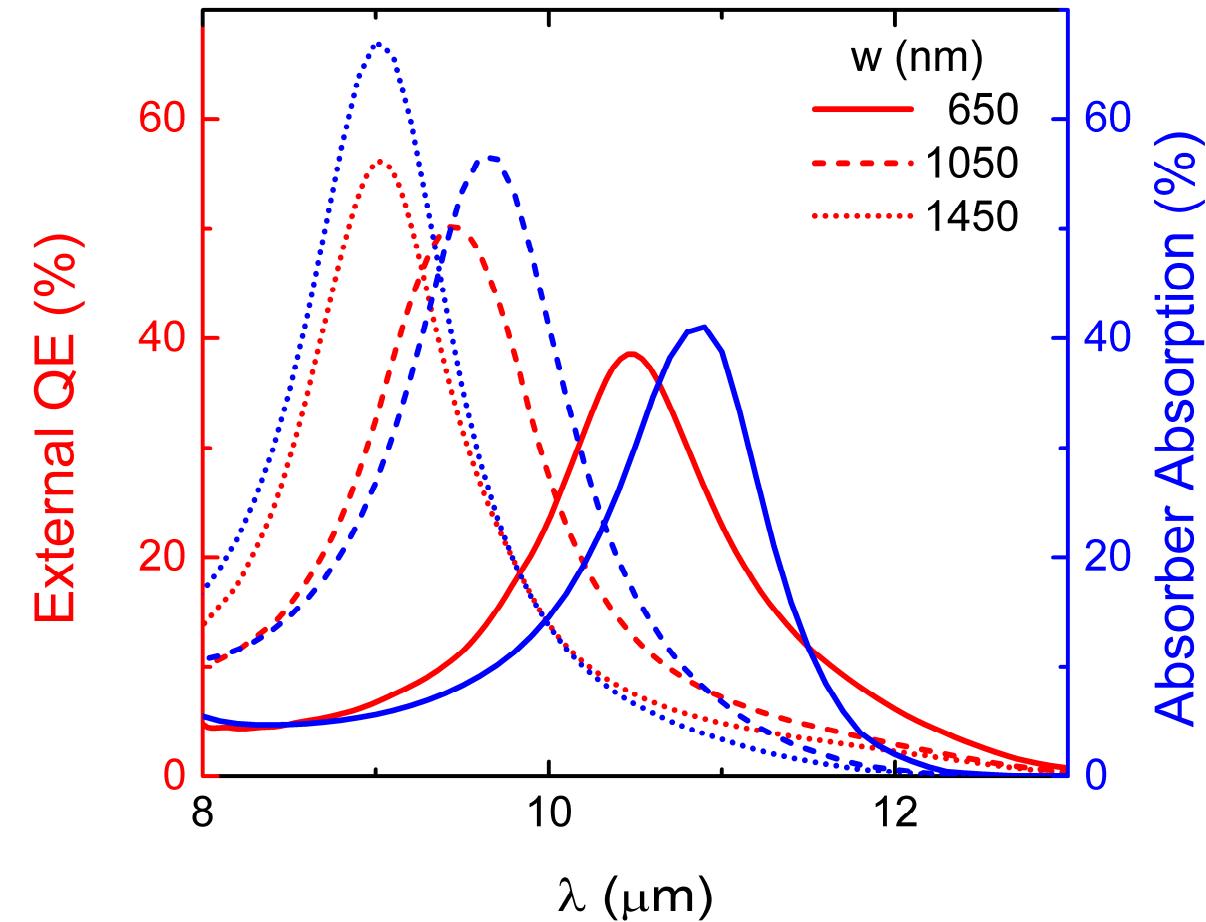
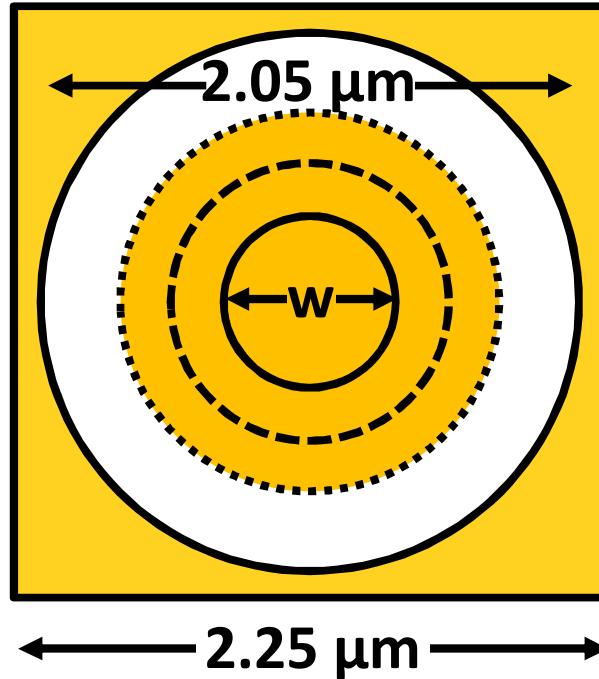
Measured Quantum Efficiency



- QE>55%: 4-5x improvement compared to non-resonant detector.
- Temperature independent spectral response: lower cooling requirements.

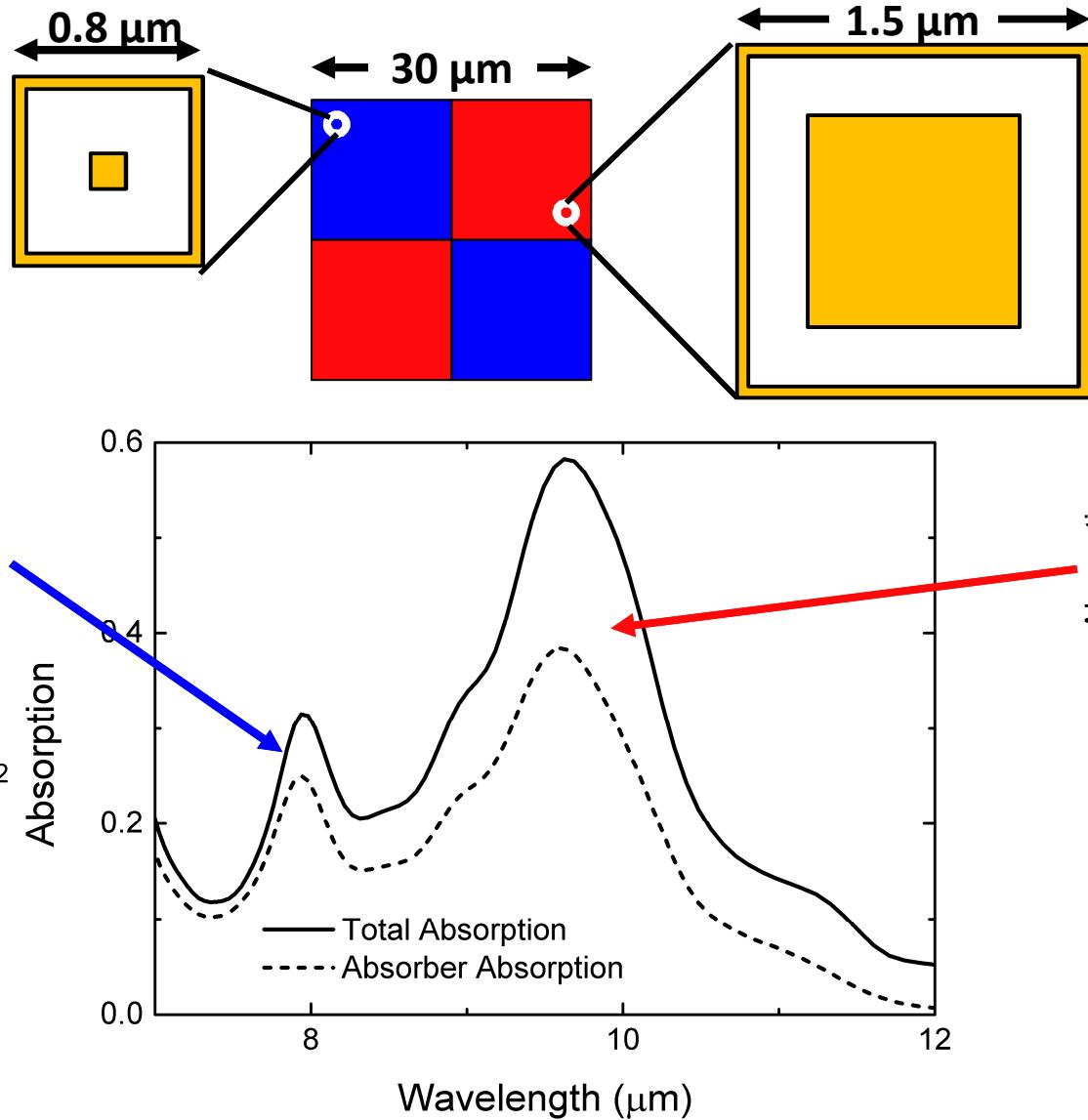


Resonance Wavelength Modification

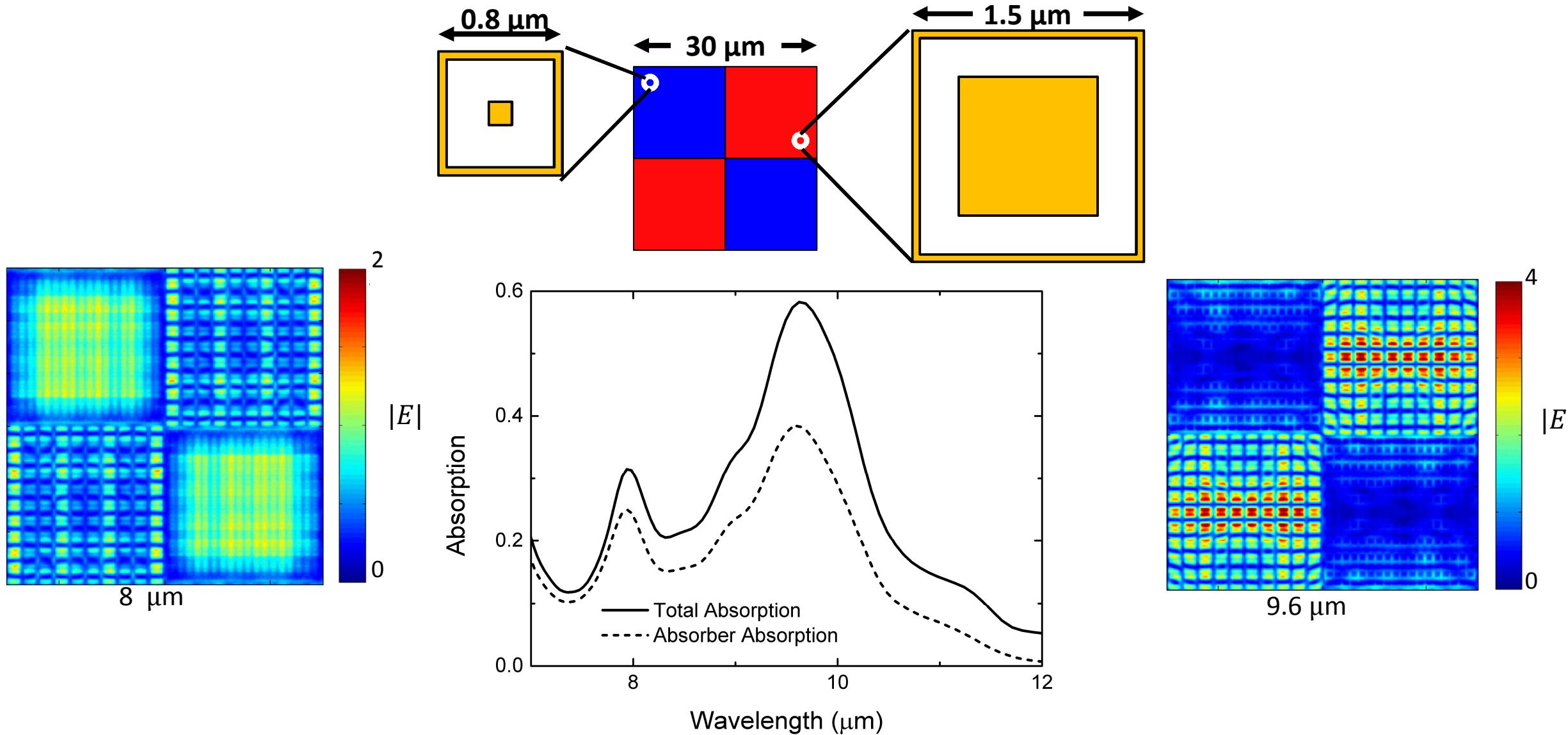


Nanoantennas enable a fixed detector stack to be resonant at multiple wavelengths without changing detector itself.

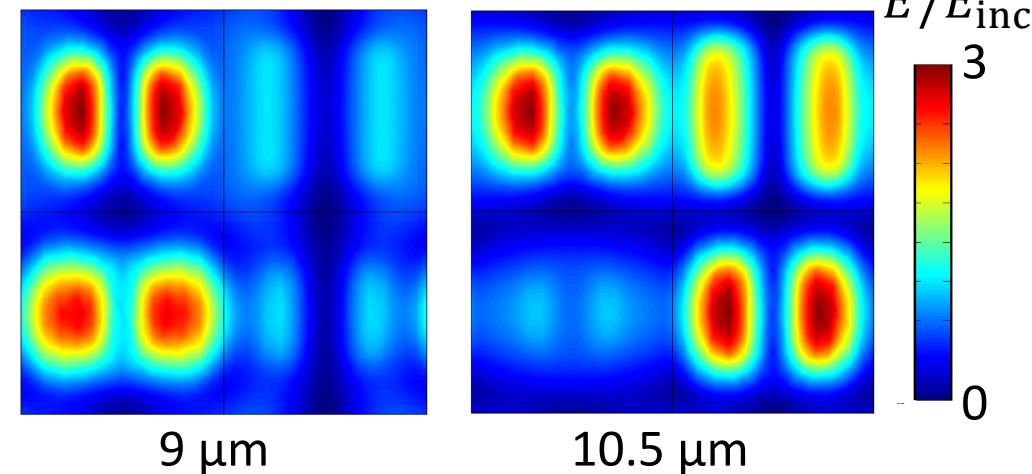
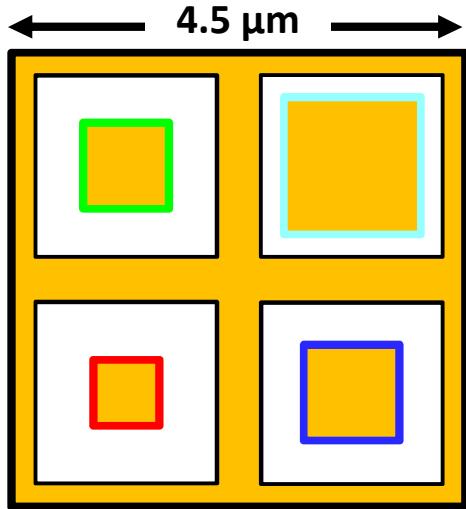
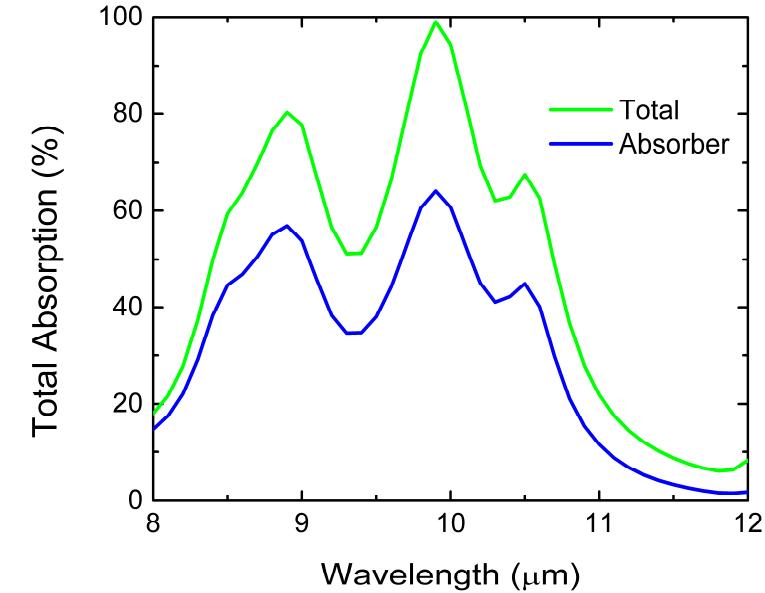
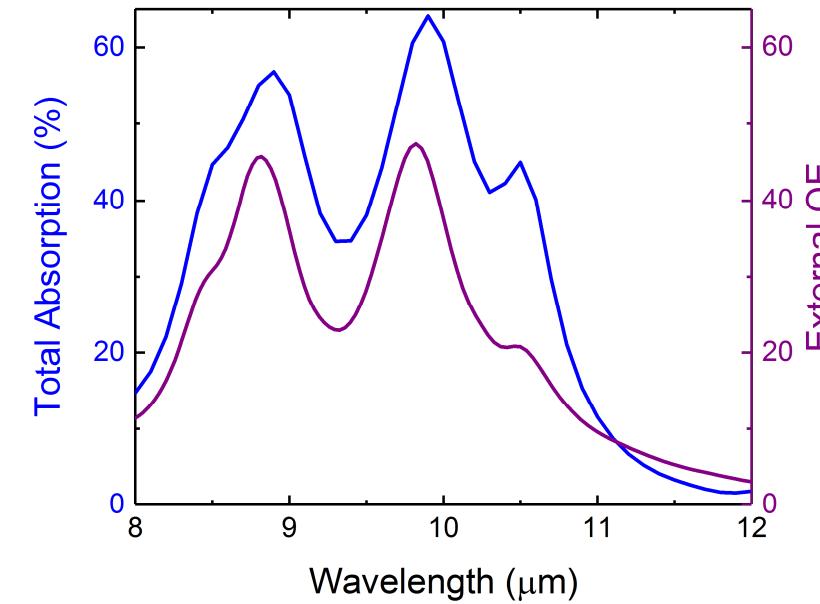
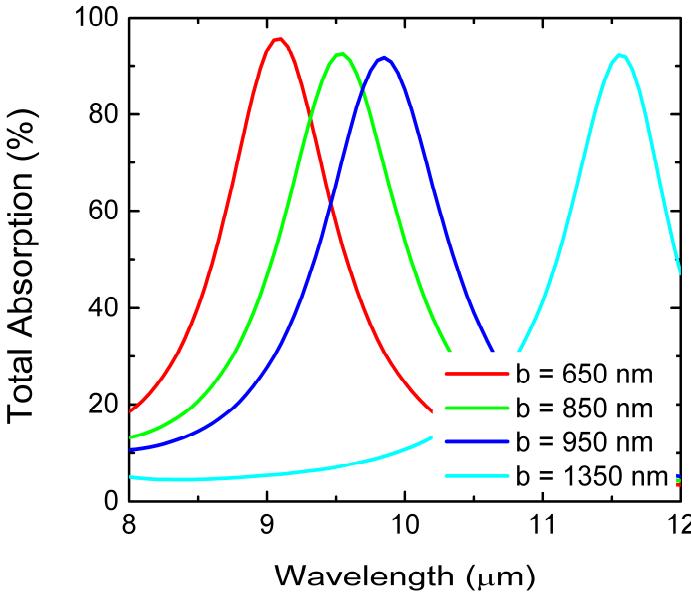
Two-Color Detections



Electromagnetic Crosstalk Analysis



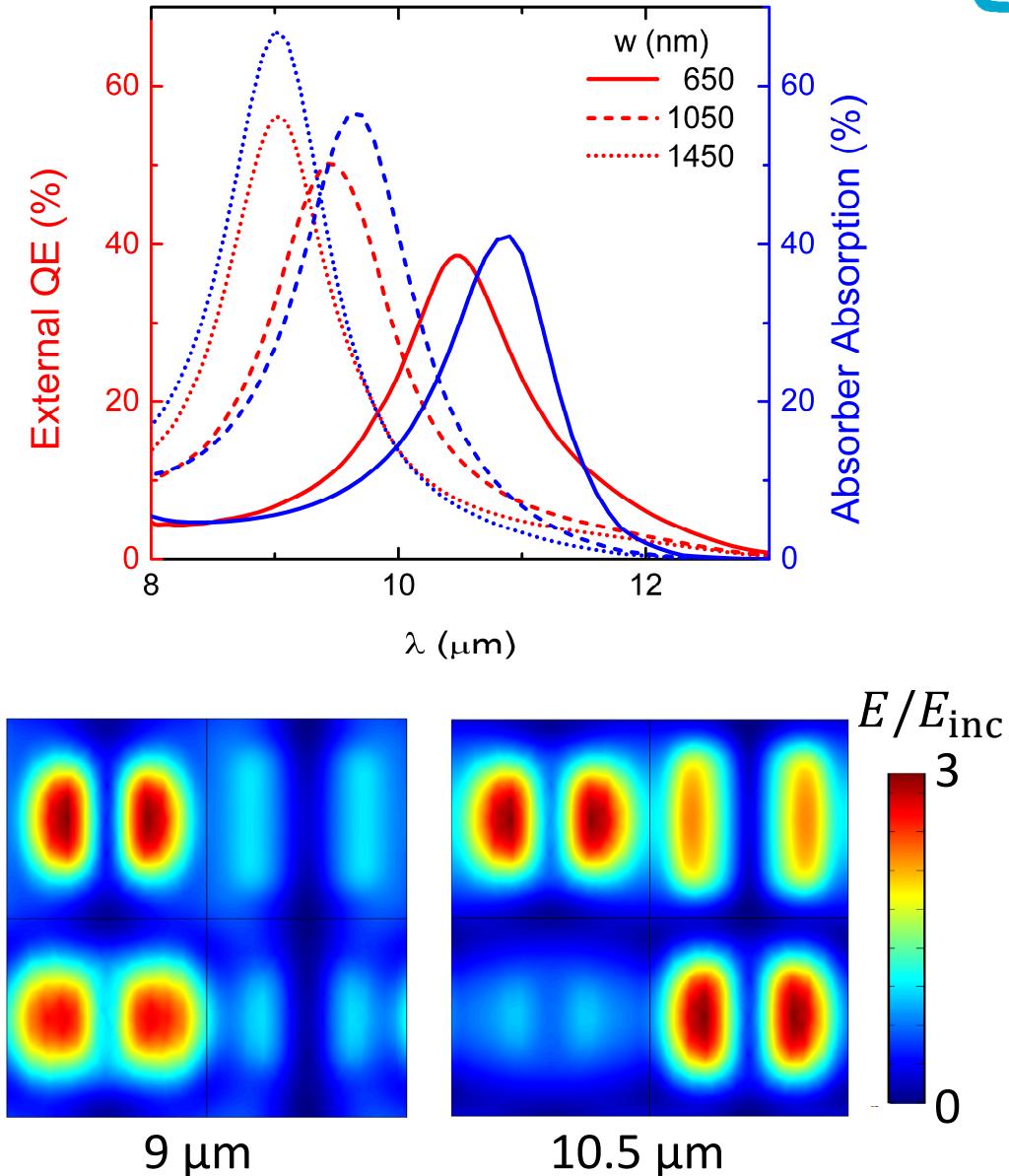
Supercell: Broadened Resonance



- Doubles FWHM of resonance.
- Enables improved QE over a broader range of frequencies.
- Polarization dependent response.

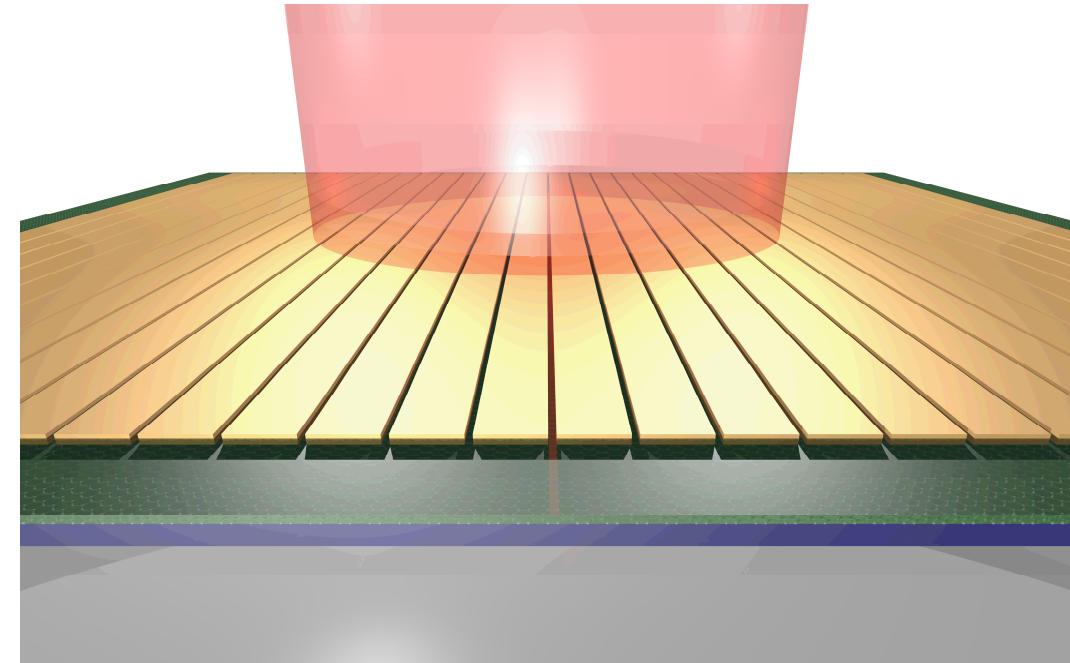
Conclusion

- Demonstrated significant gains in QE with reduction in absorbing volume.
- Control of detector response without changing detector itself.
- Broadband resonant response
- Examined two color detectors



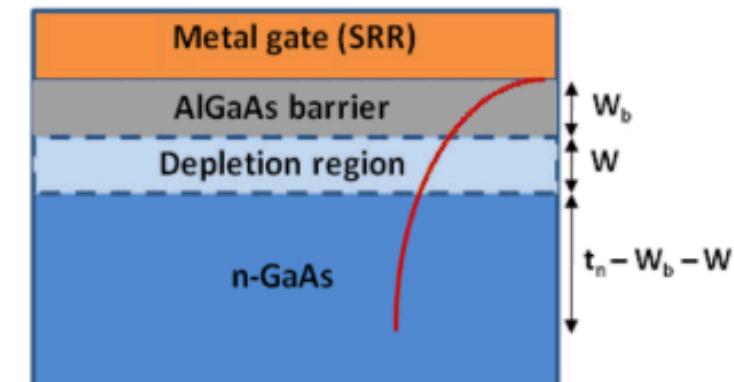
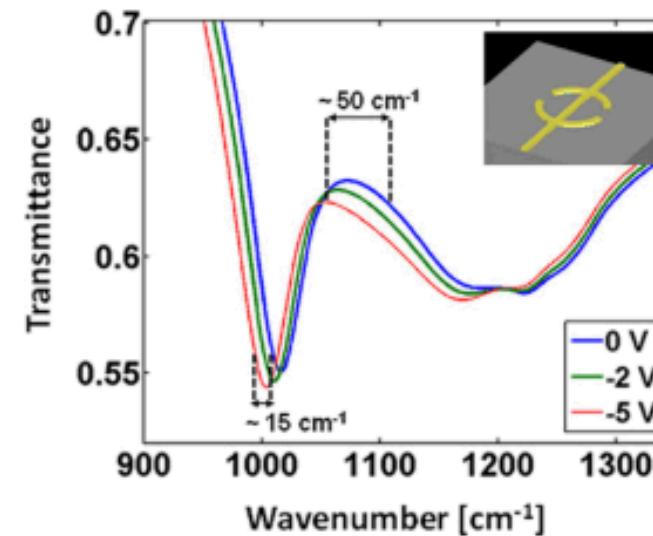
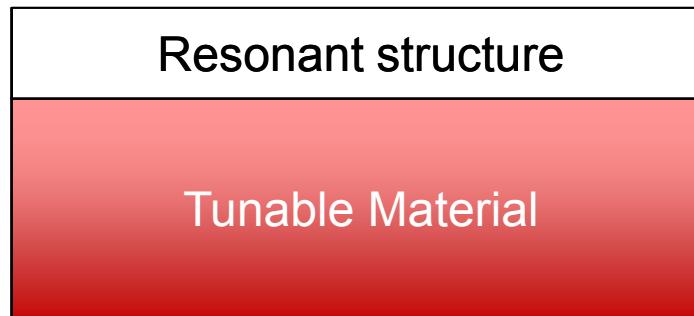
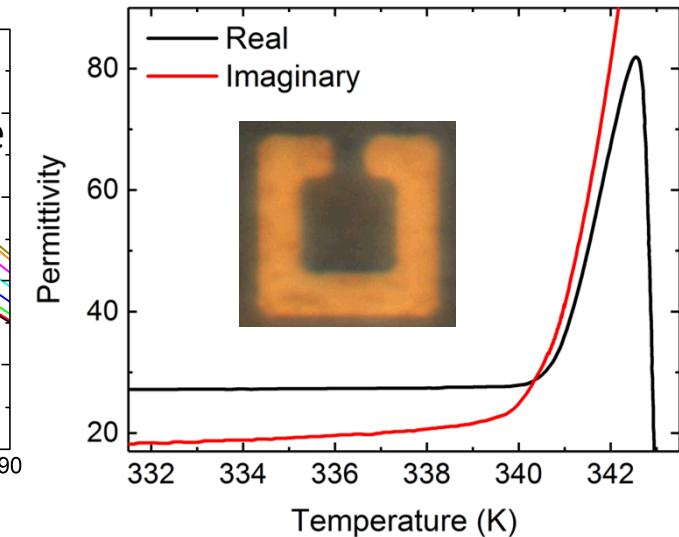
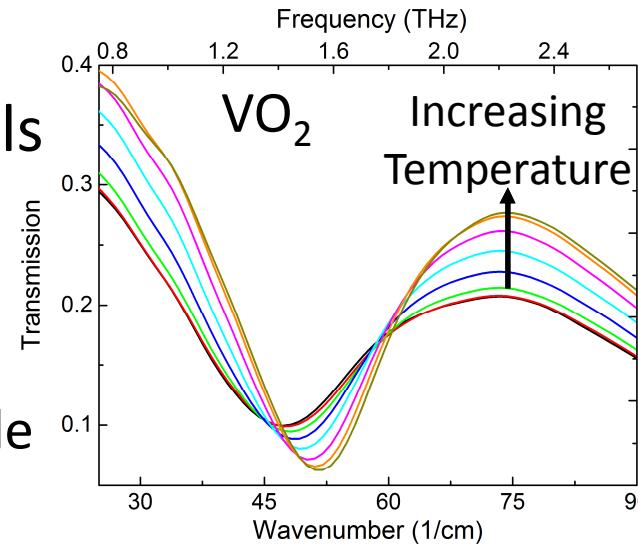
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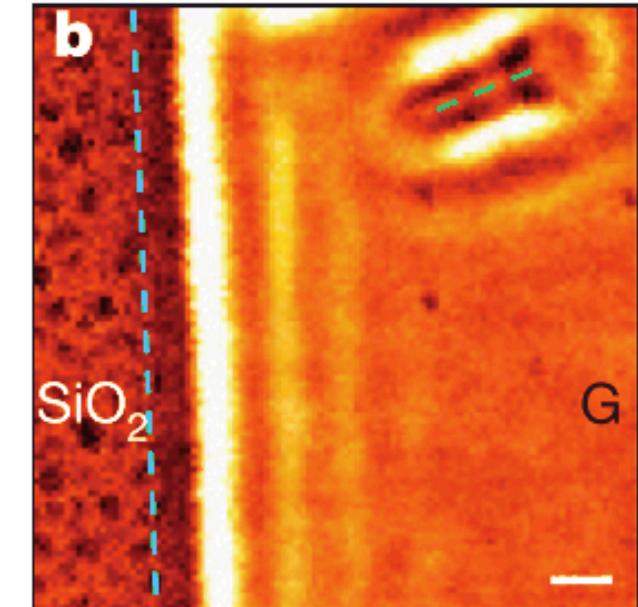
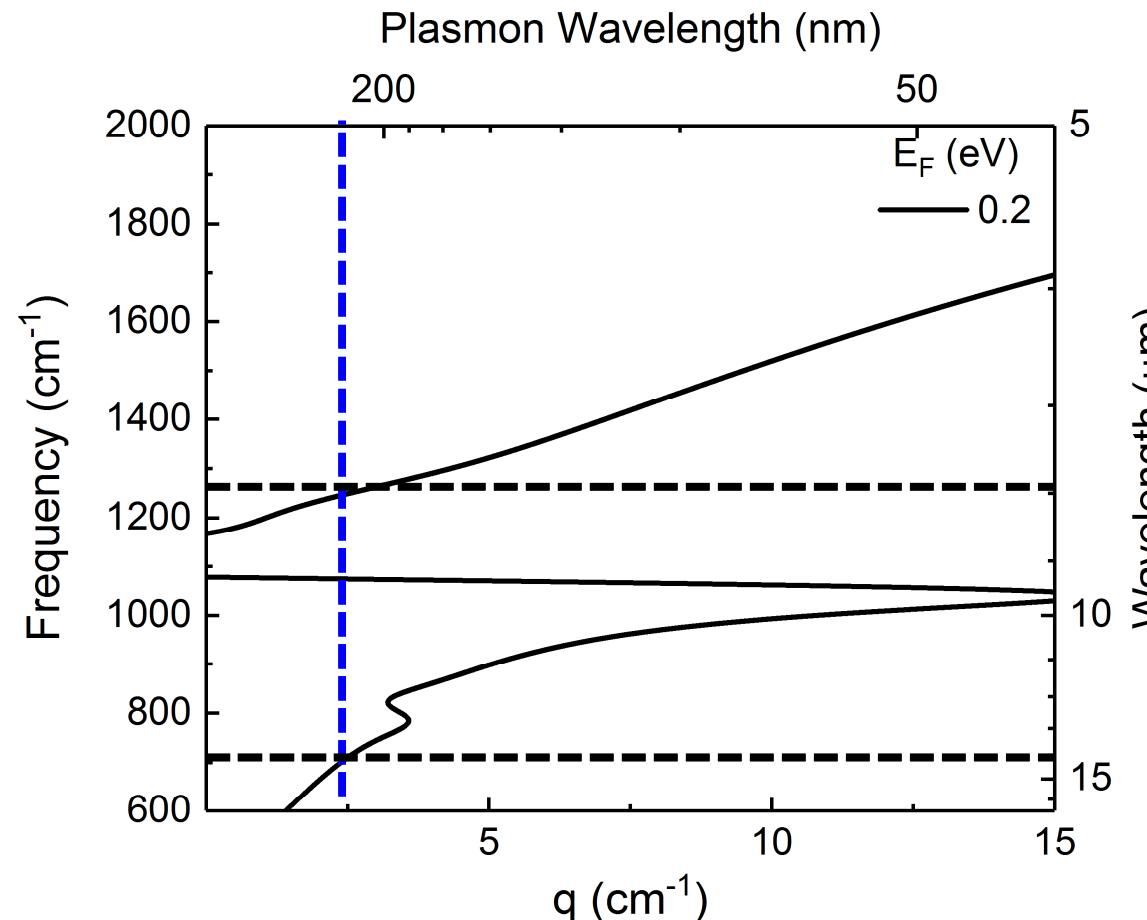
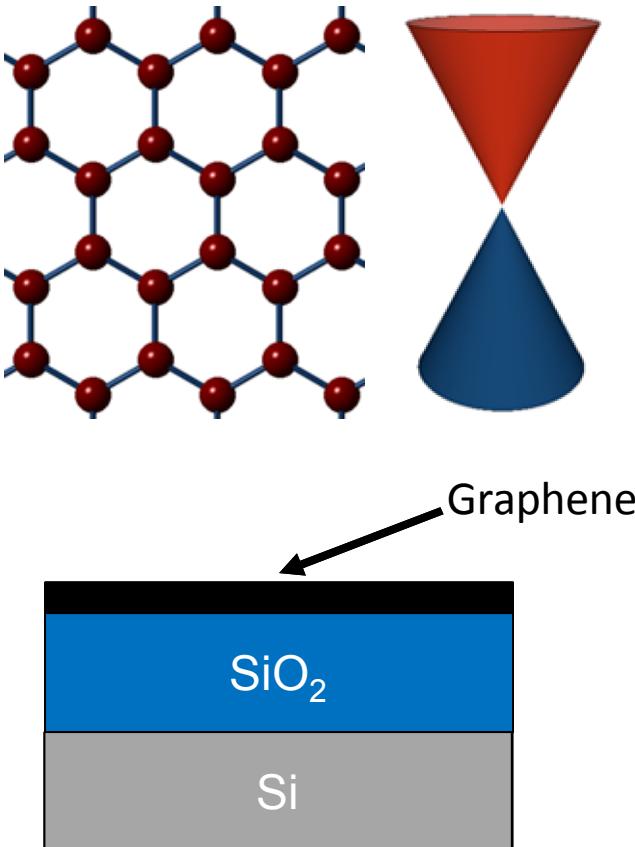
Tunable materials

- Metal-Insulator transition materials
 - VO_2 , V_2O_3 , NdNiO_3
 - Thermally triggered
- Tunable bulk plasmonic materials
 - CdO , semiconductors, indium tin oxide
 - Electrically triggered



$$\omega_p \propto \sqrt{n}$$

Plasmonic Tuning in Graphene



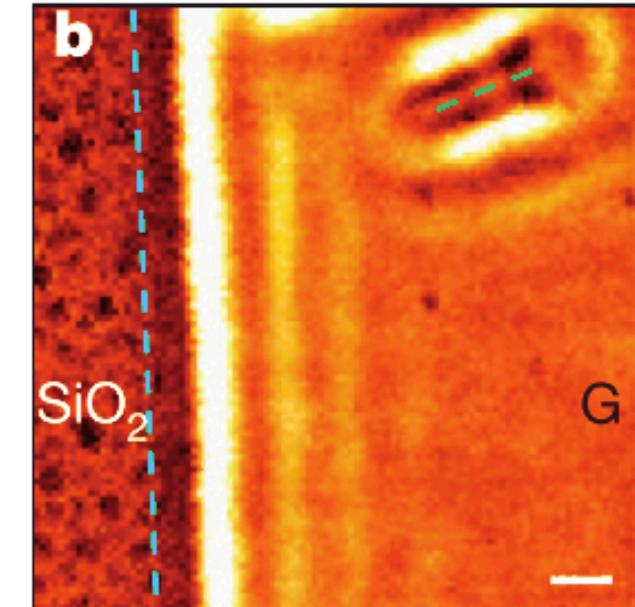
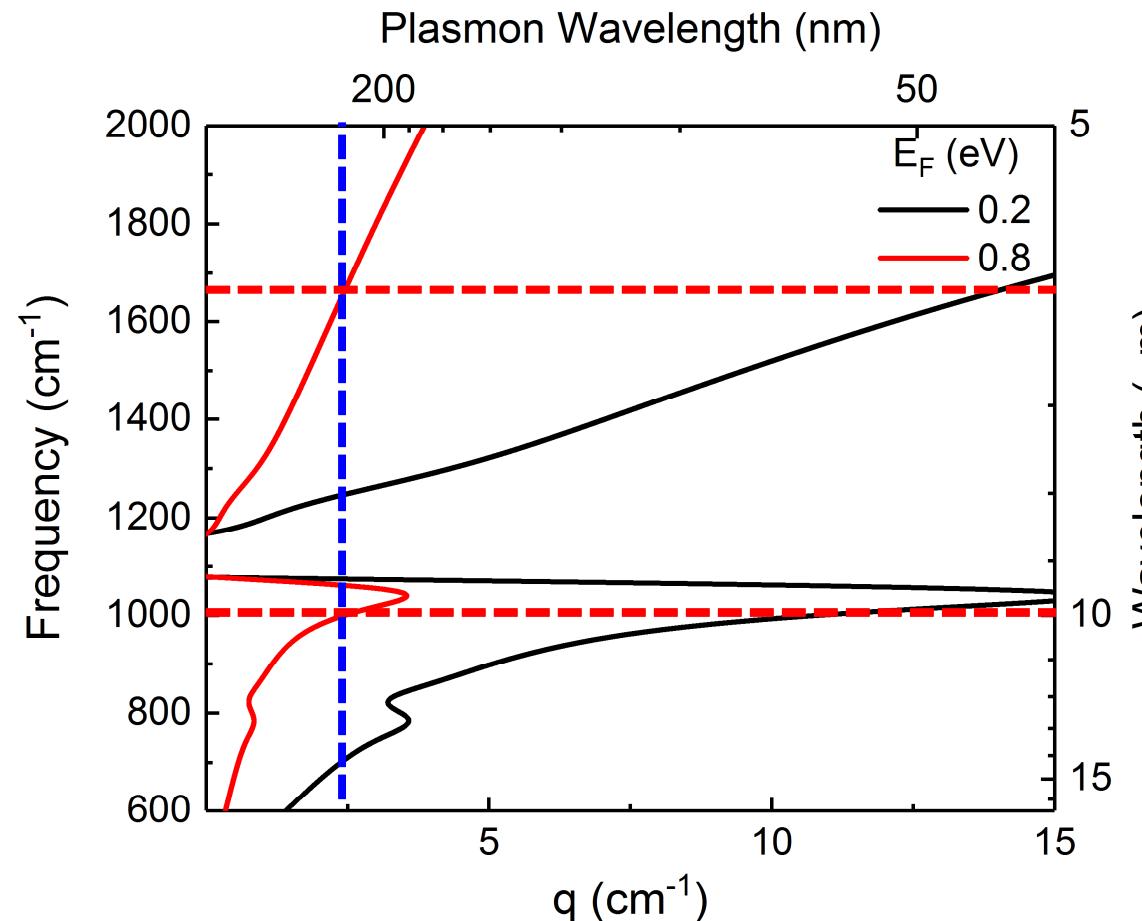
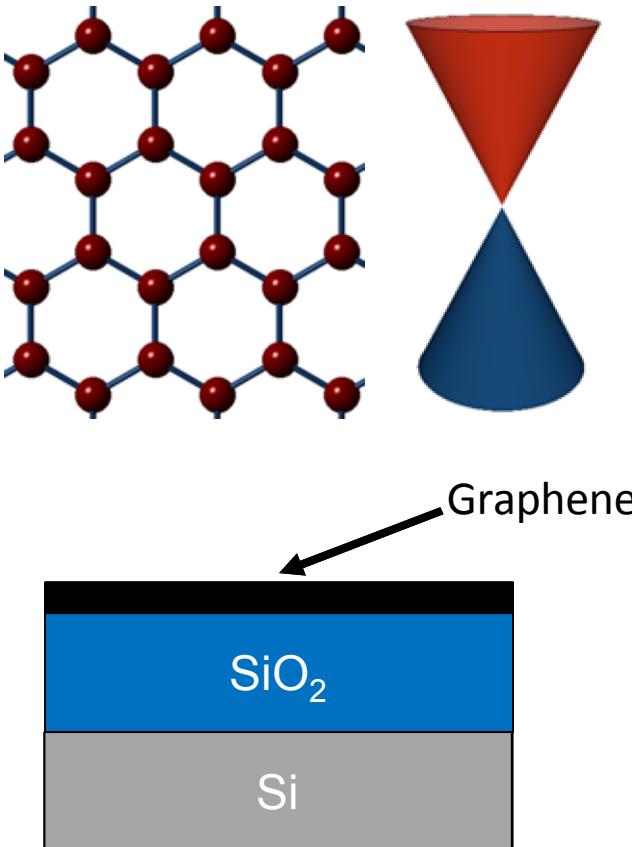
Plasmonic response easily tuned through carrier injection

Z. Fei, et al, Nano Lett. 2011, 11, (11), 4701-5.

J. Chen, et al, Nature 487 (7405), 77-81 (2012).

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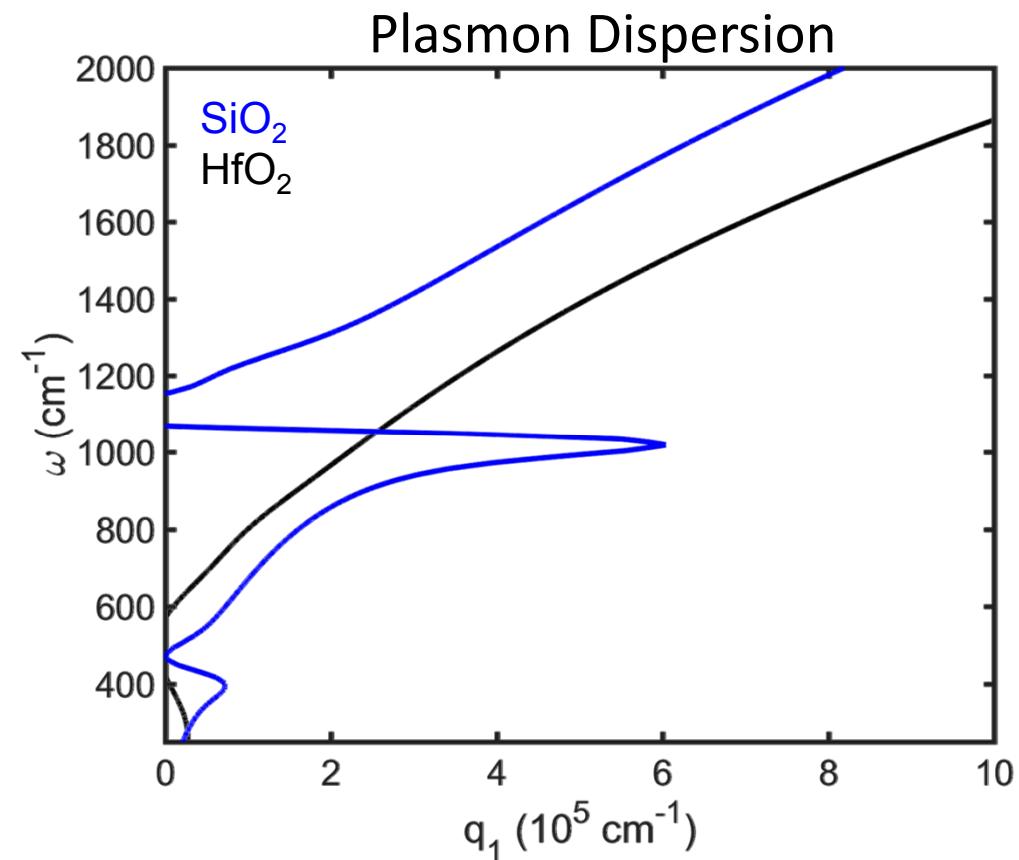
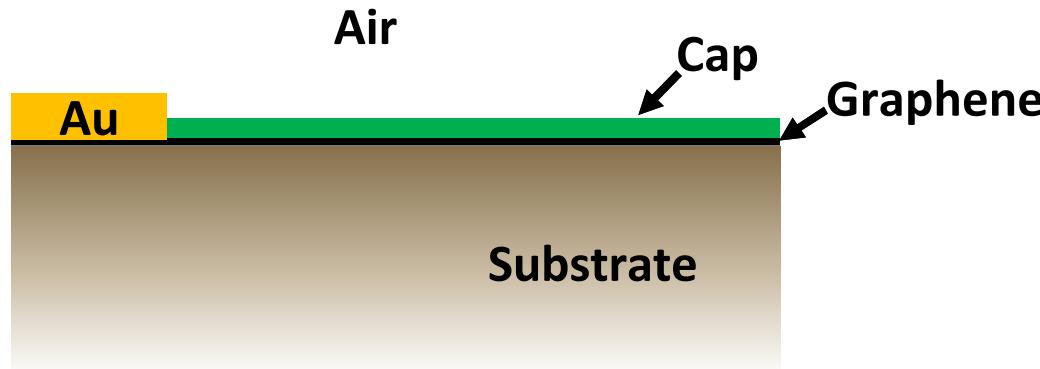
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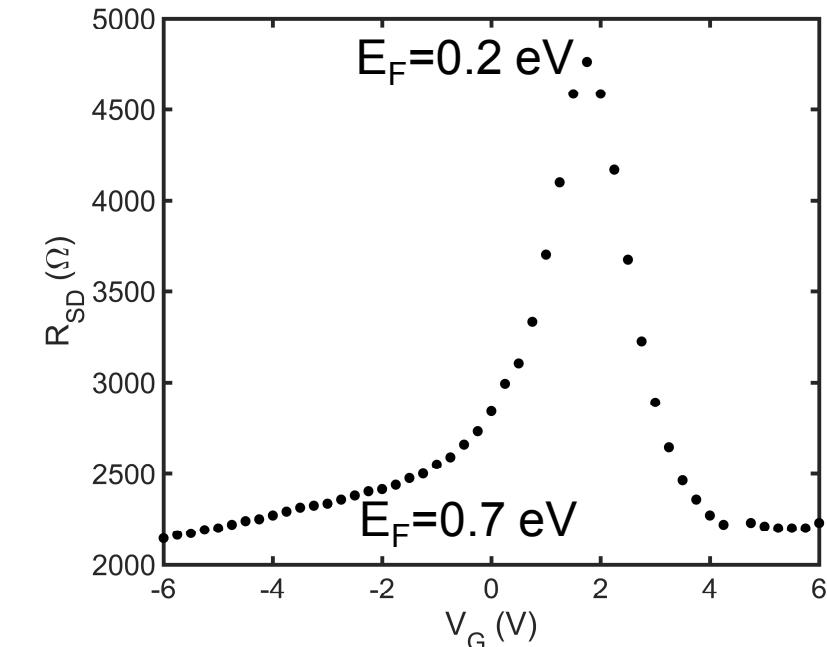
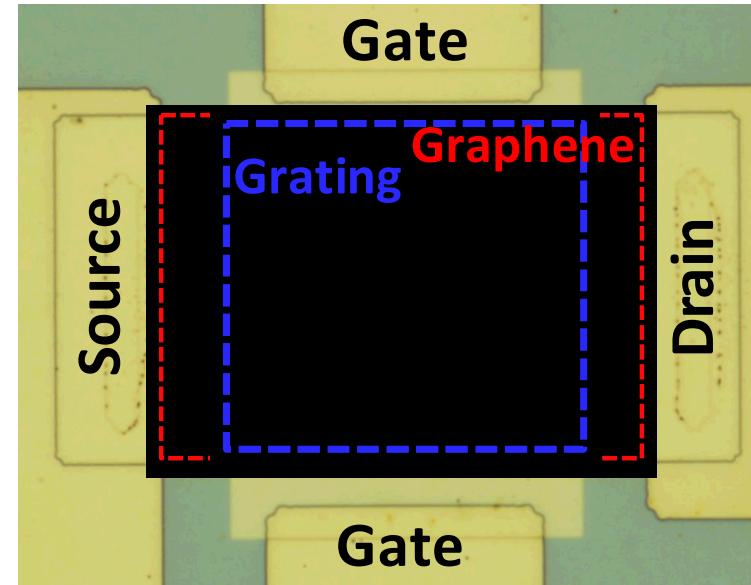
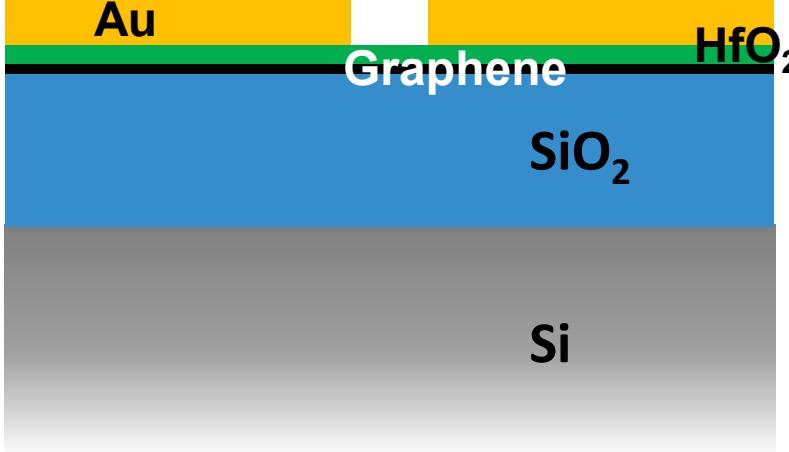
Limitations of Graphene

Graphene changed by environment and fabrication methods

- Fermi level pinning
- Environmental degradation
- Plasmon dispersion modification

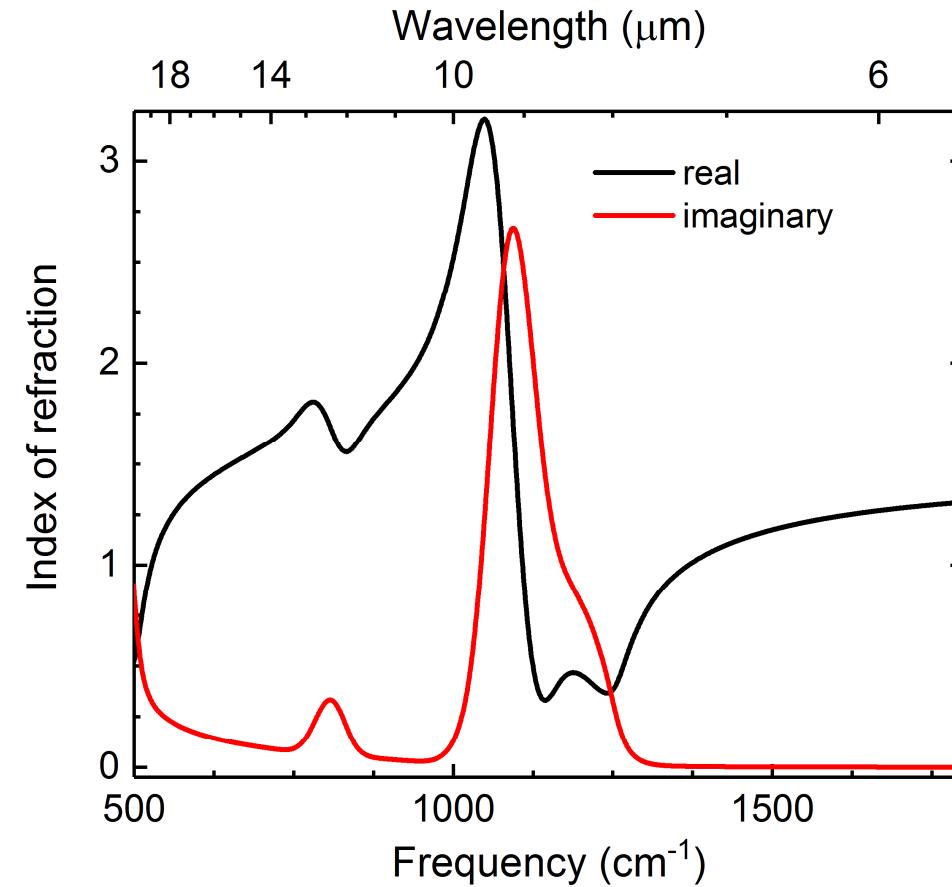
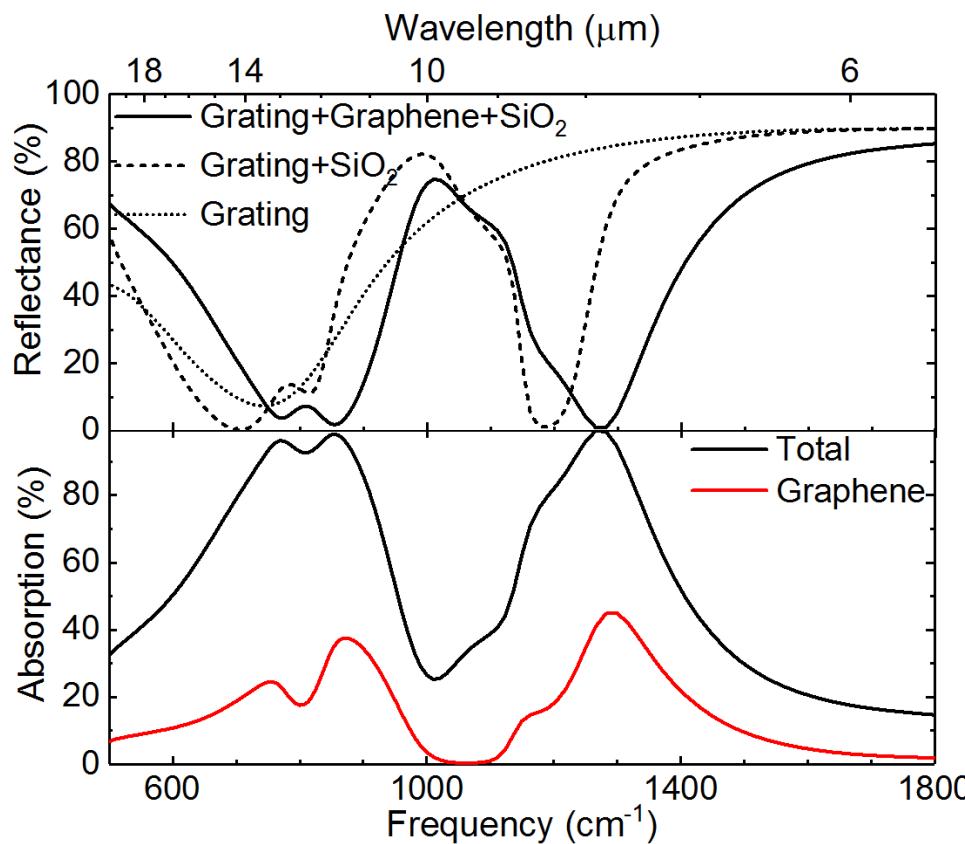


Device Design



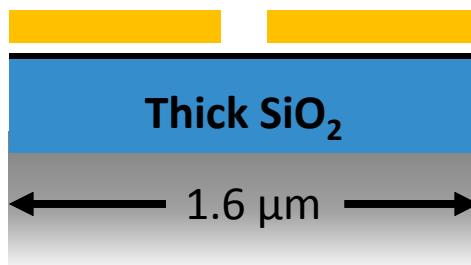
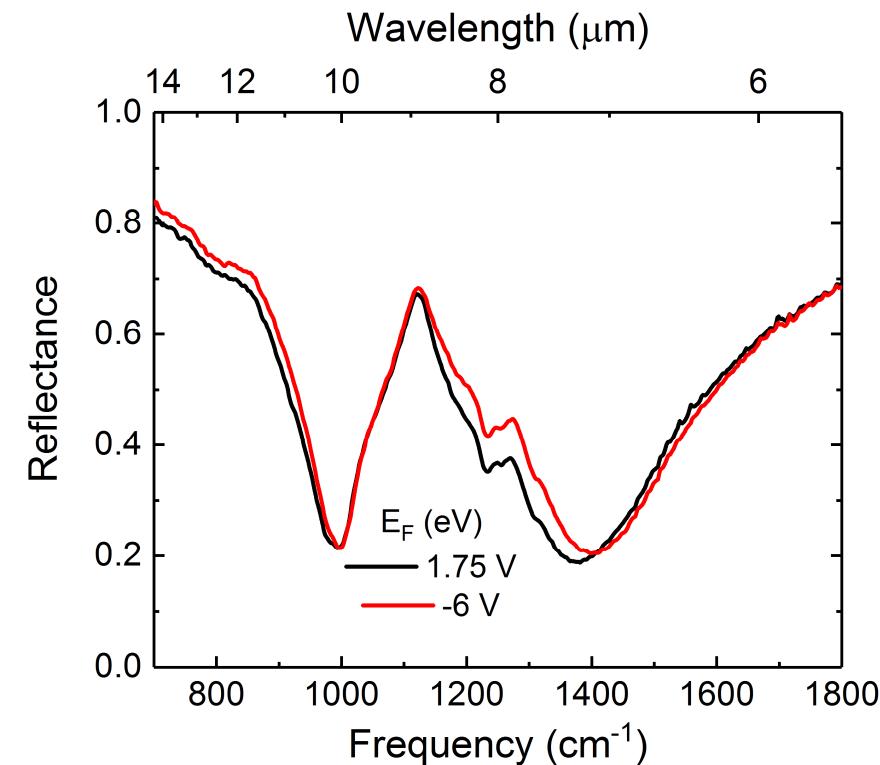
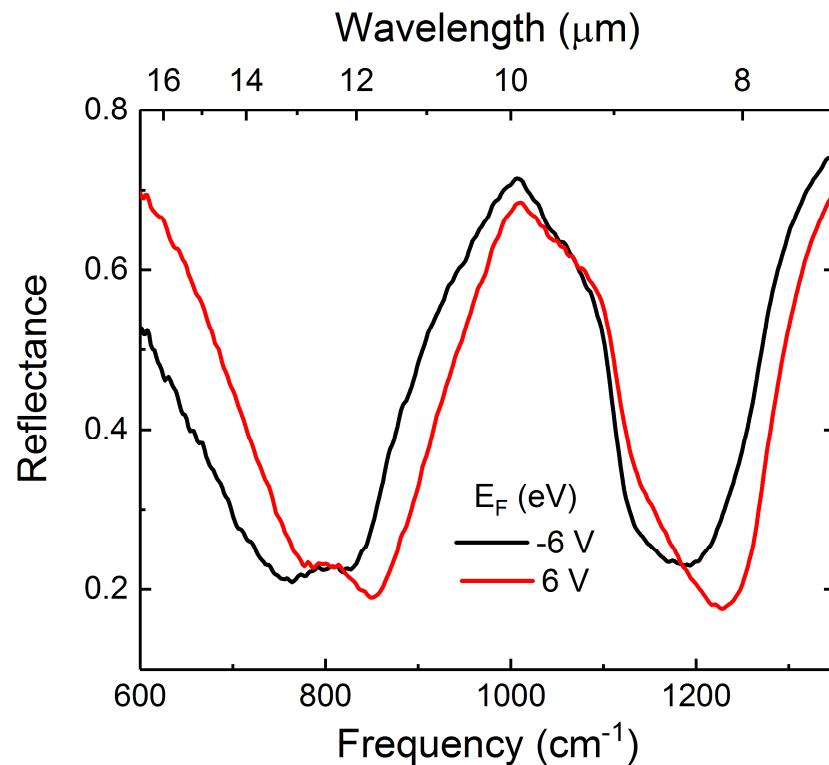
- Scalable (continuous and unpatterned large-area CVD graphene)
- Protected graphene (capping layer)
- Avoid metal-graphene contact

Building the Filter Response

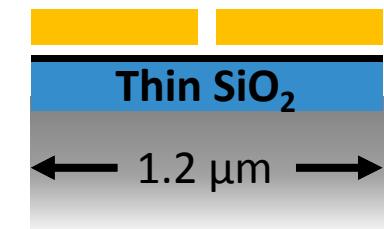


- Presence of SiO₂ increases resonance Q-factors
- Dielectrics can modify resonance location.

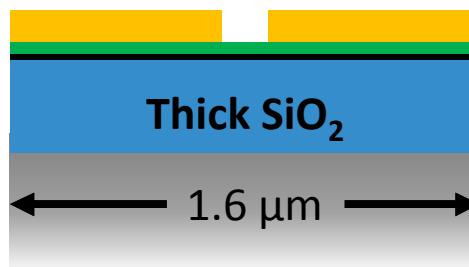
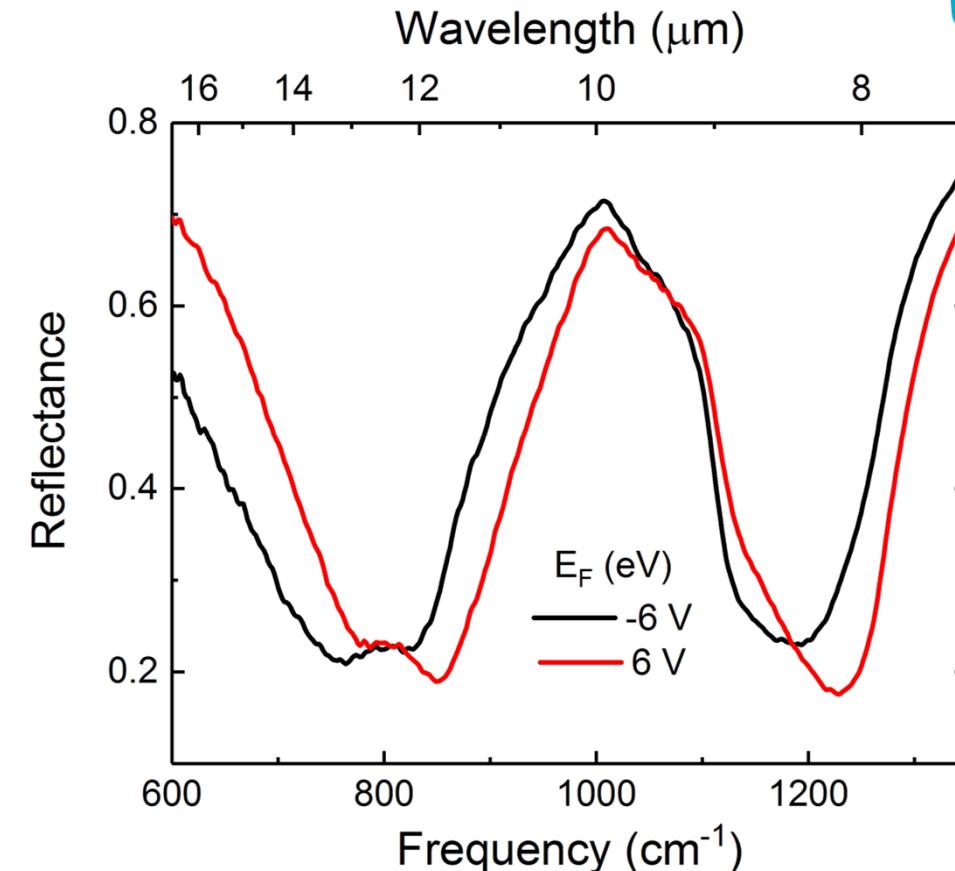
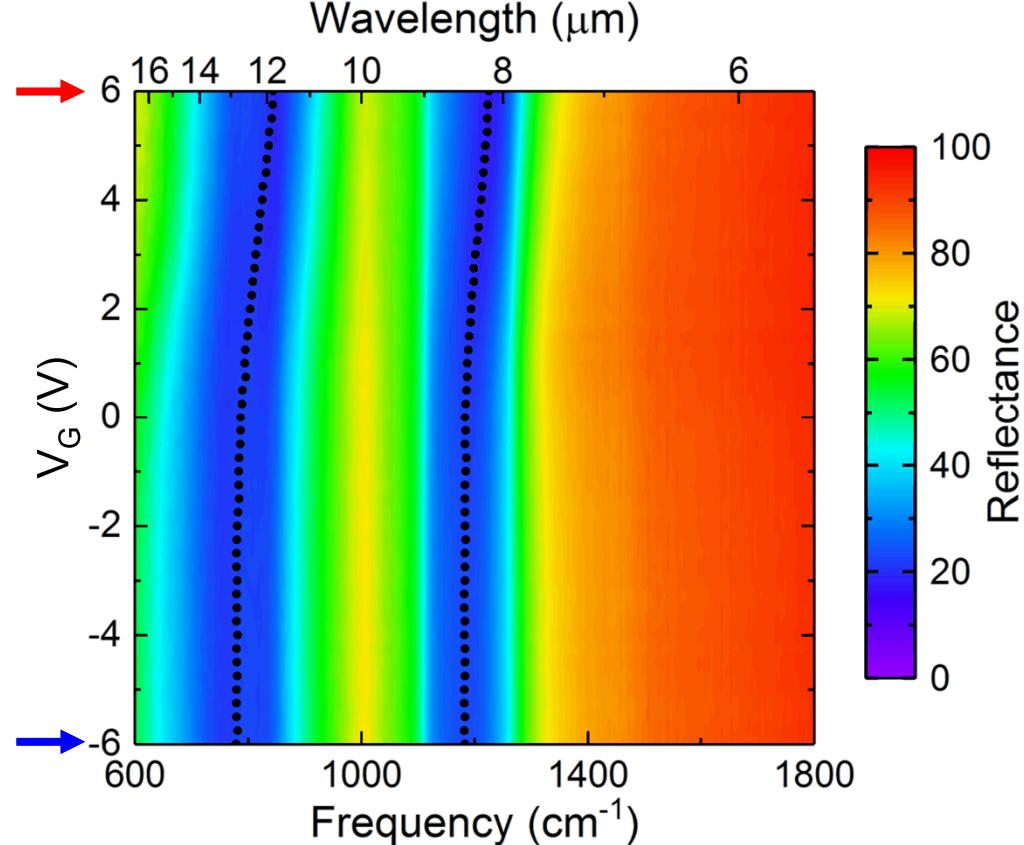
Measured Reflectance



- Spectral shifts depend on geometry.
- Location and tuning amount can be designed.

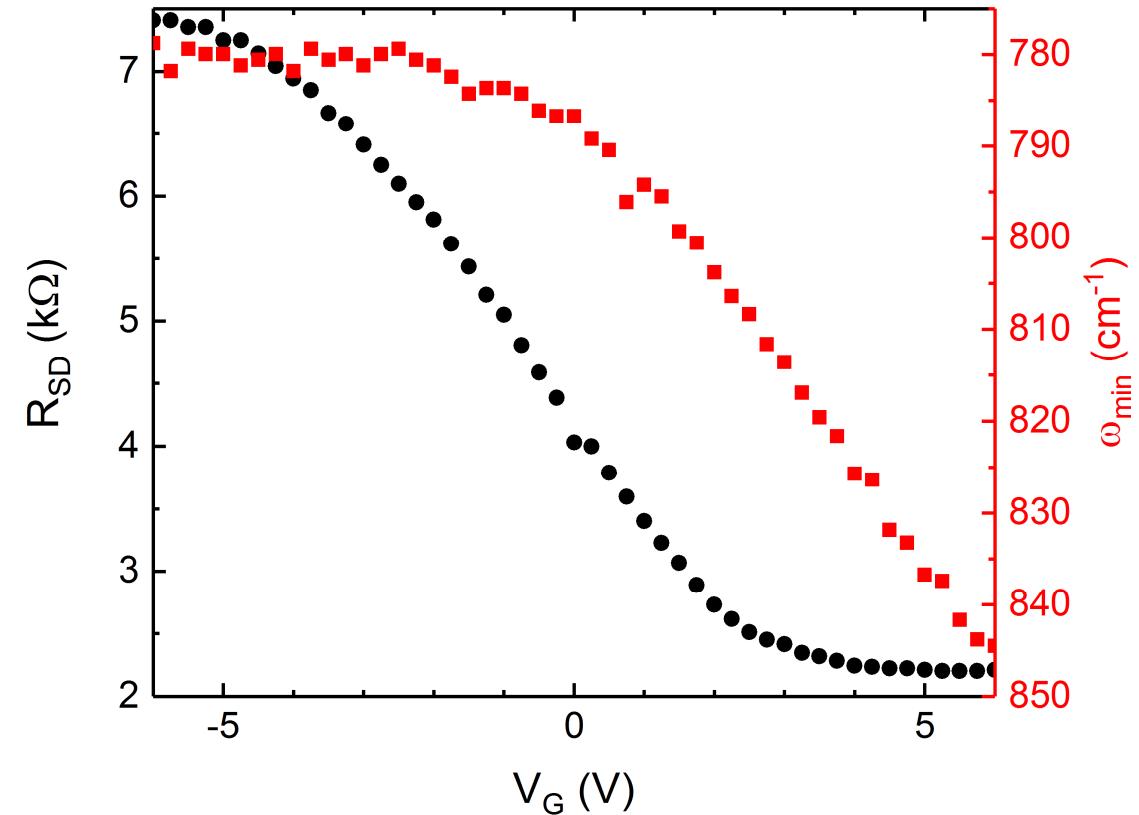
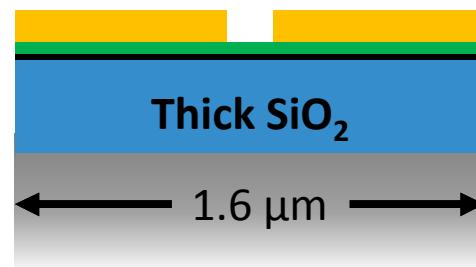
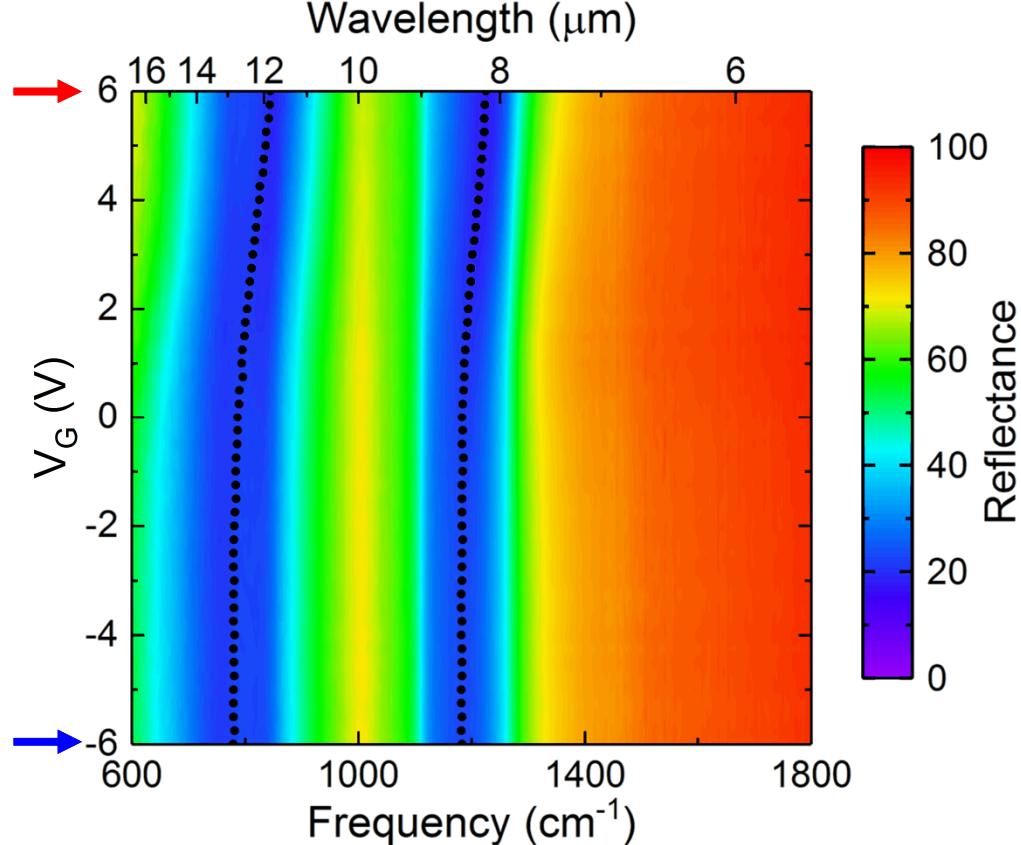


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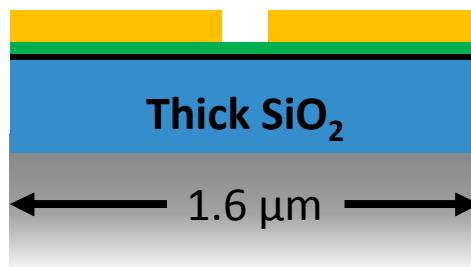
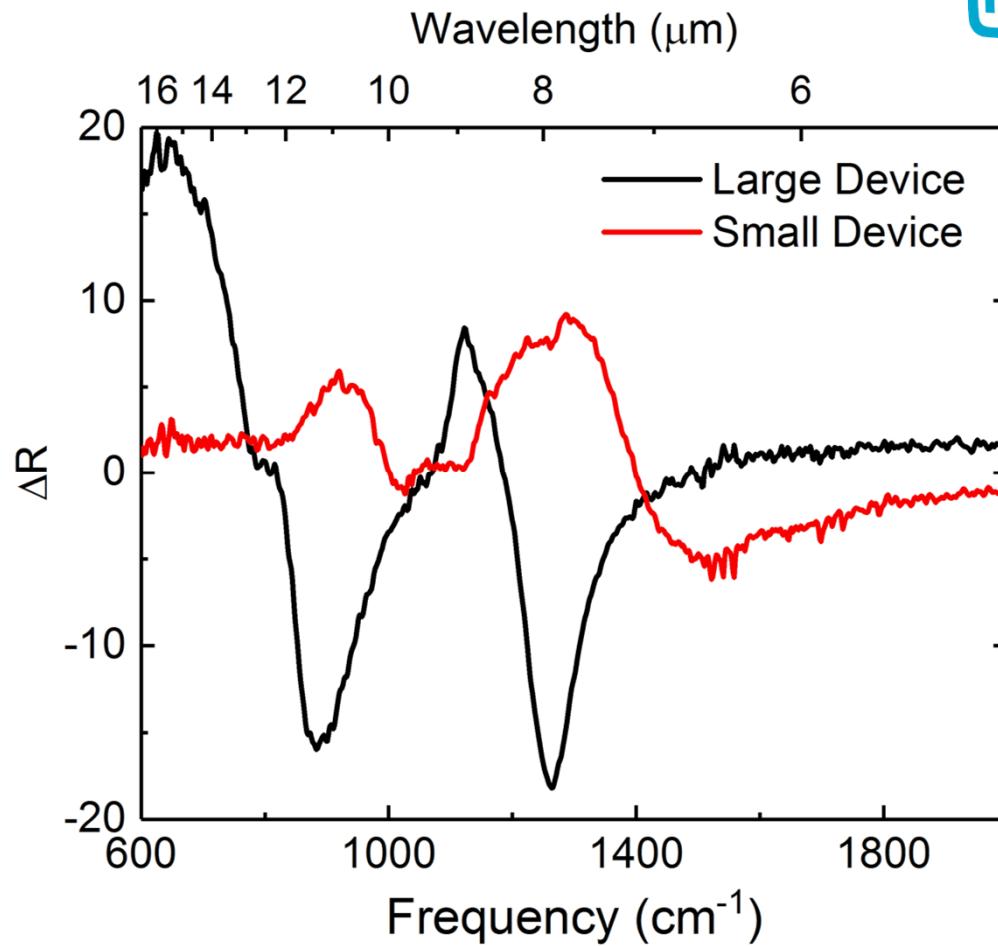
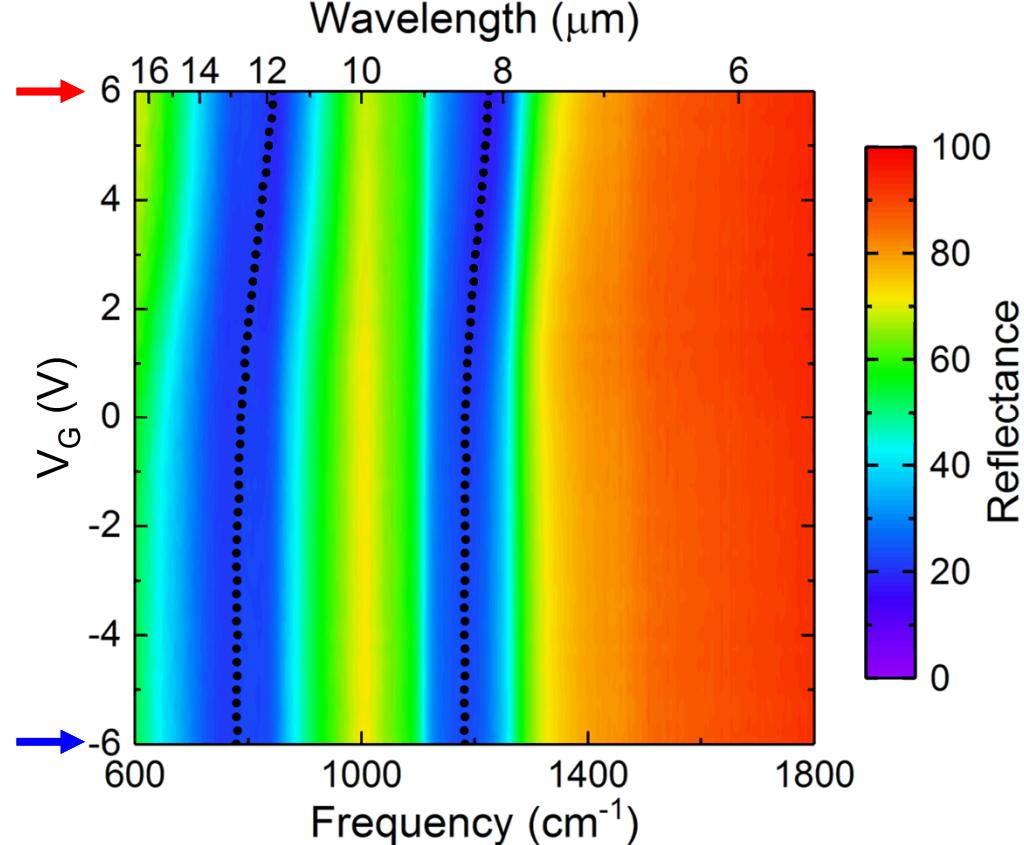
- Shift in position of two resonances simultaneously.
- Larger shifts at lower frequencies.
- Spectral shift depends on both grating design and SiO₂ thickness.

Measured Reflectance



- Shift in position of two resonances simultaneously exceeding 50 cm⁻¹.
- Larger shifts at lower frequencies.
- Spectral shift depends on both grating design and SiO₂ thickness.

Measured Reflectance

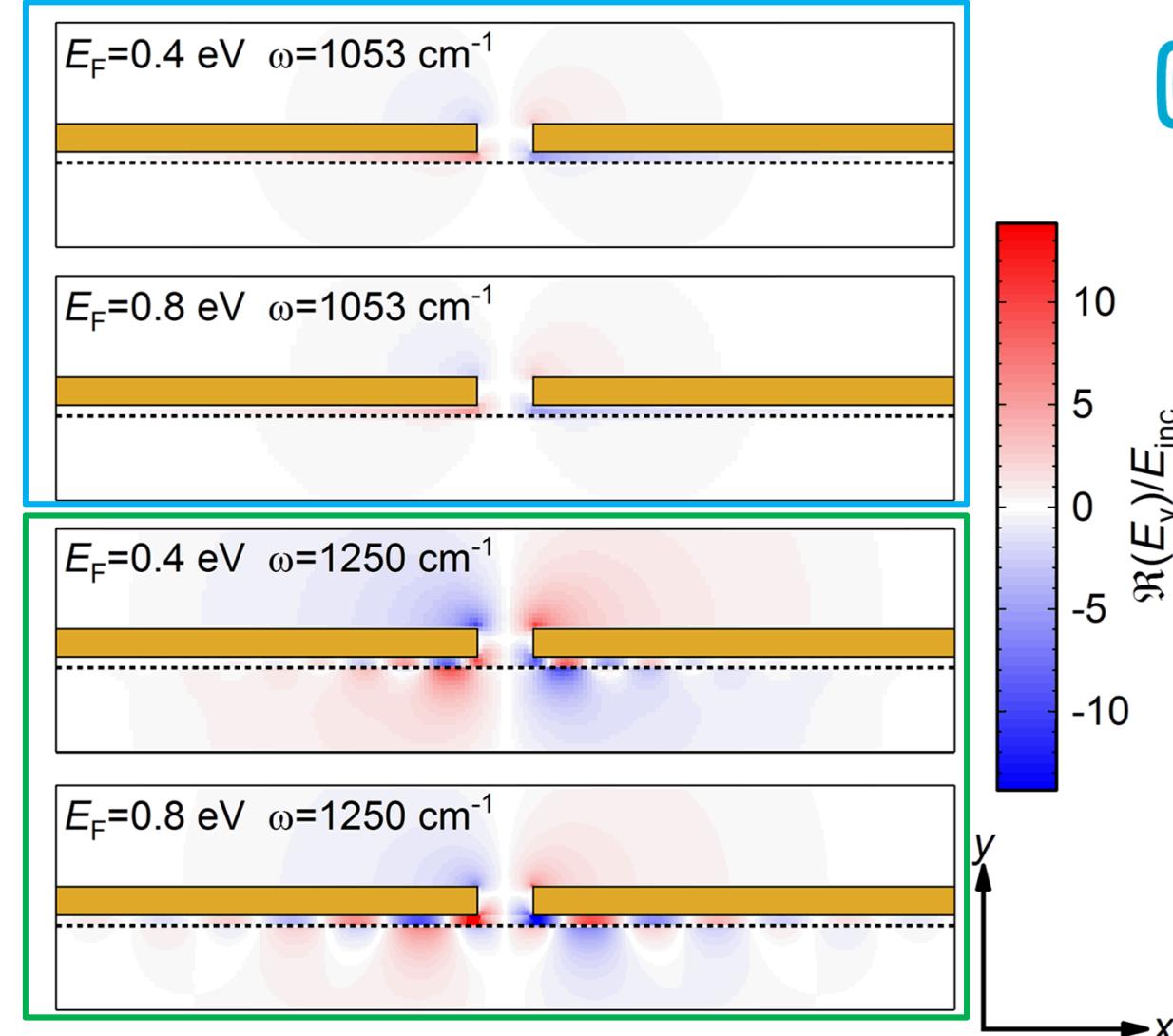
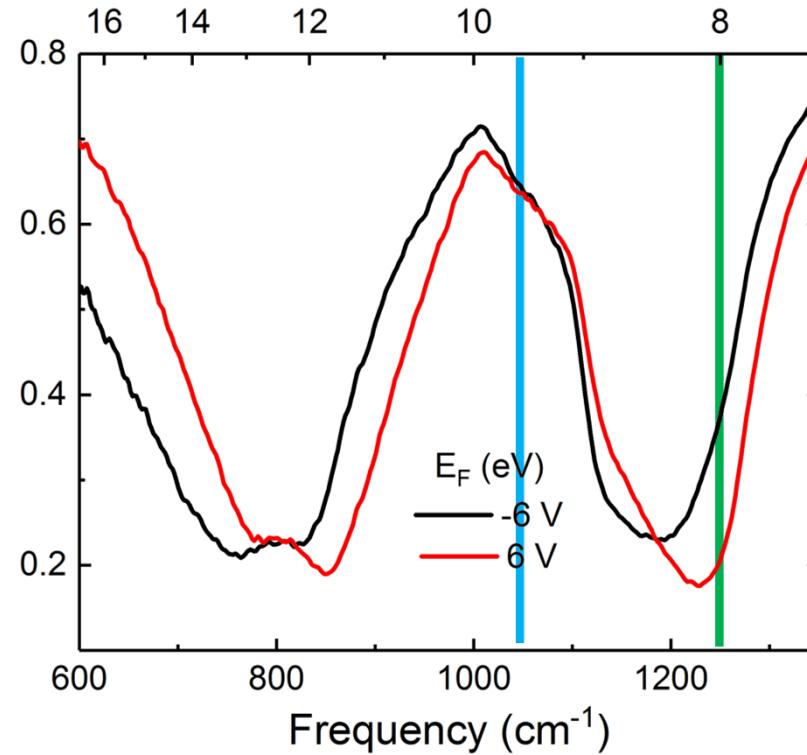


- Shift in position of two resonances simultaneously exceeding 50 cm^{-1} .
- Larger shifts at lower frequencies.
- Spectral shift depends on both grating design and SiO₂ thickness.
- Change in reflectance near 20%.

Origin of Tuning

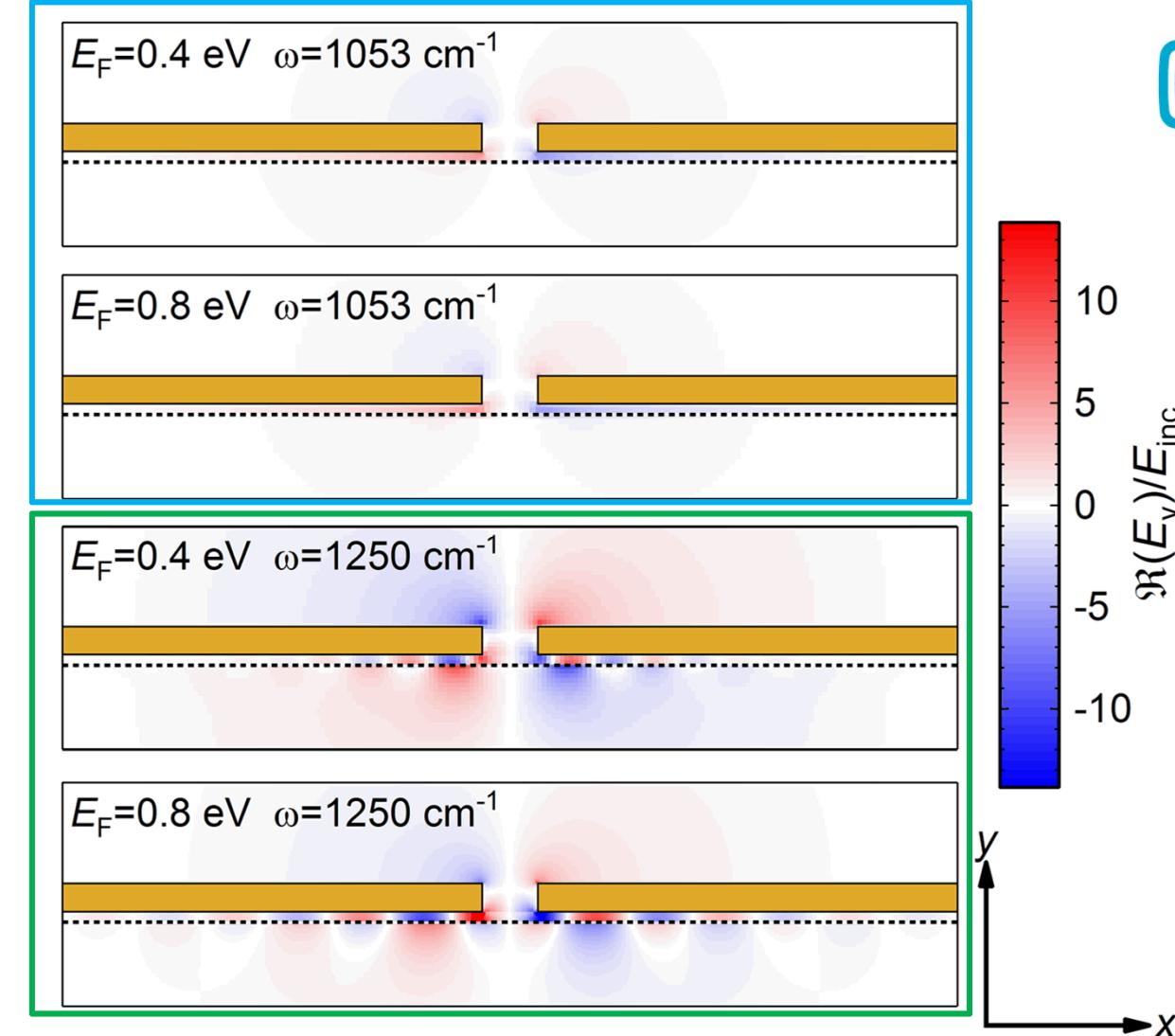
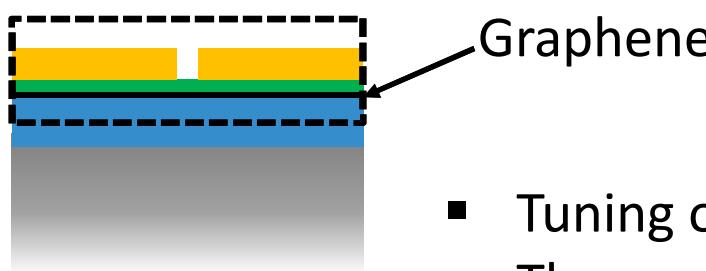
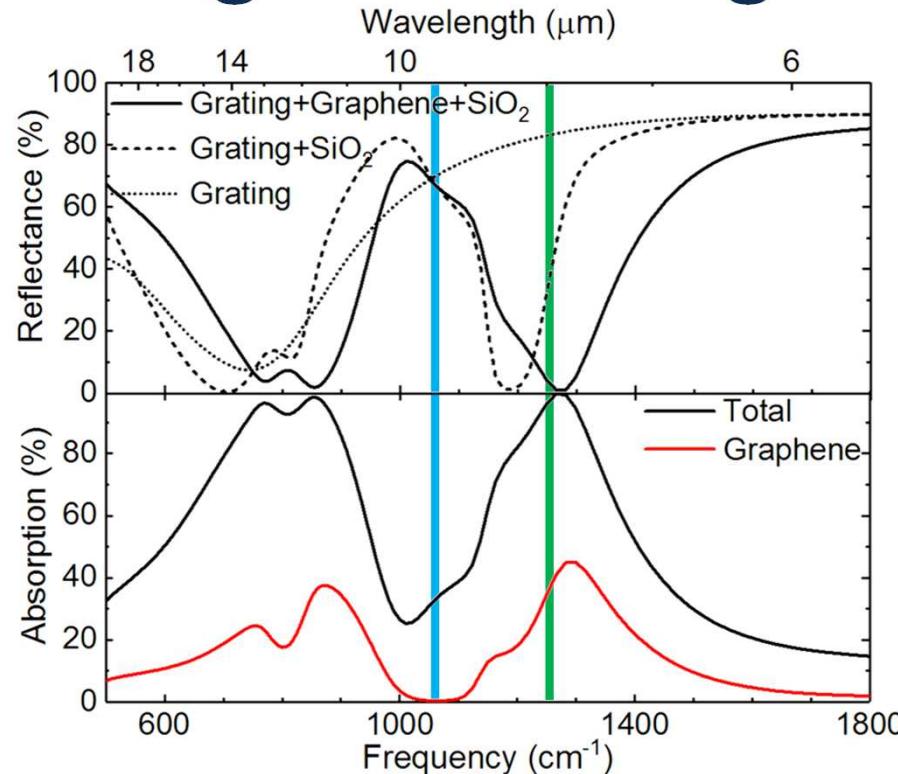
Wavelength (μm)

Reflectance



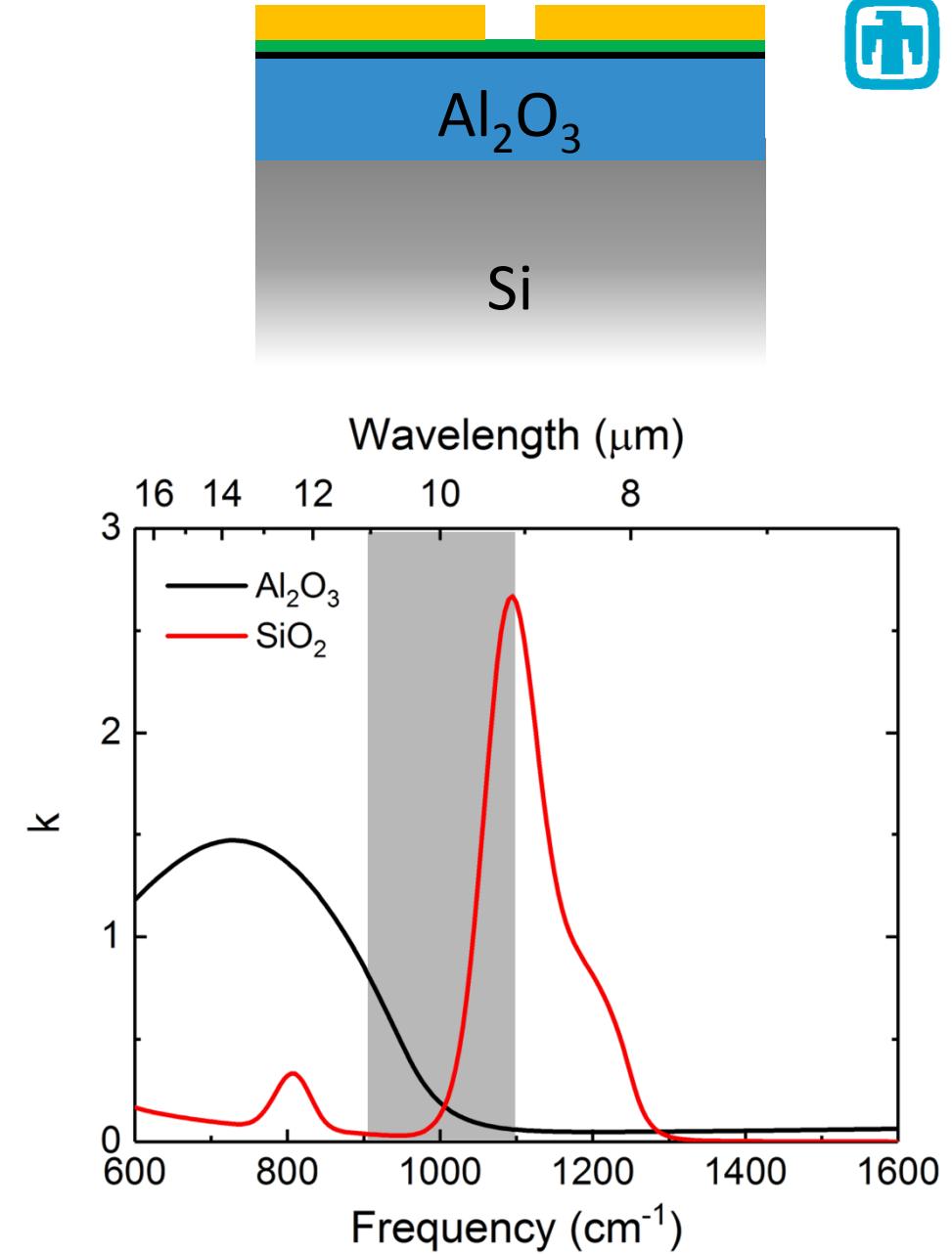
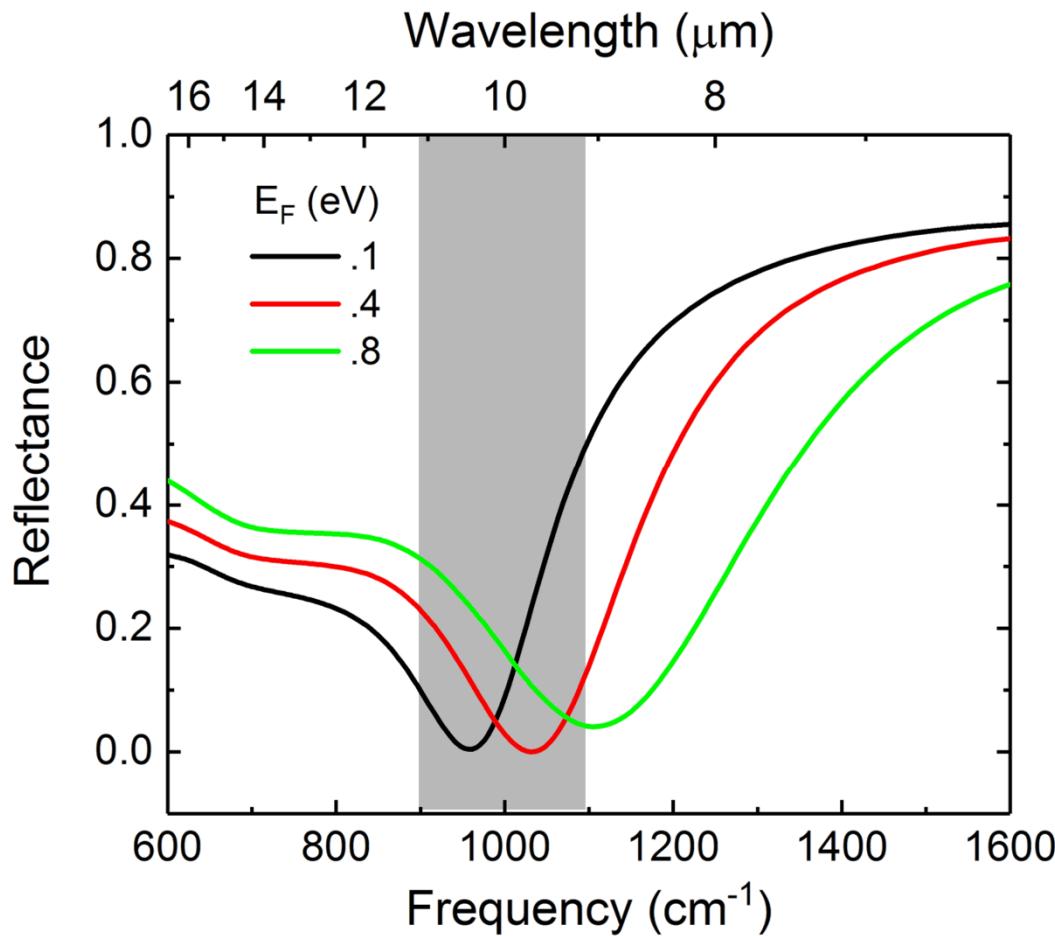
- Tuning occurs only where plasmon is excited and modified with Fermi energy.
- These regions are determined by dielectric cladding layers making them selectable.

Origin of Tuning

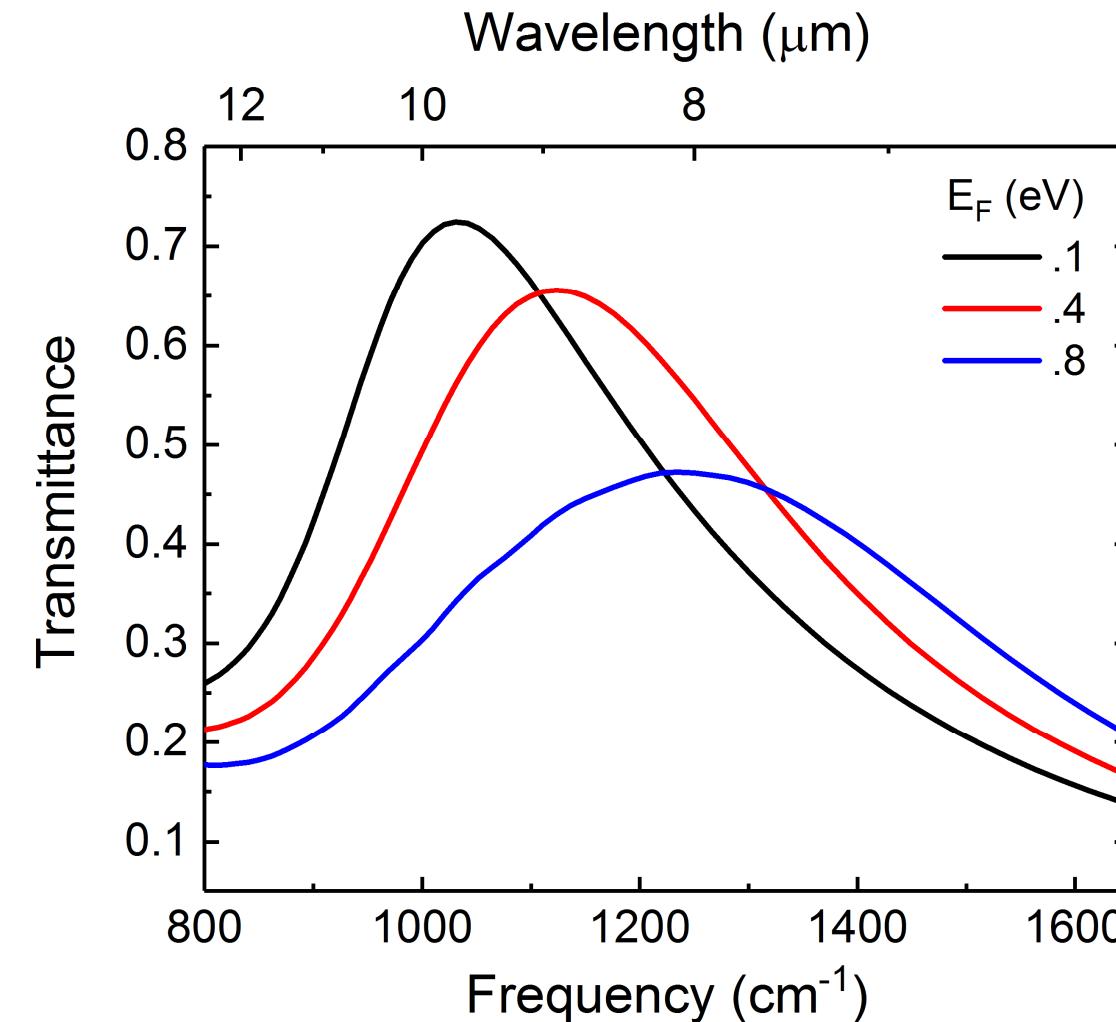
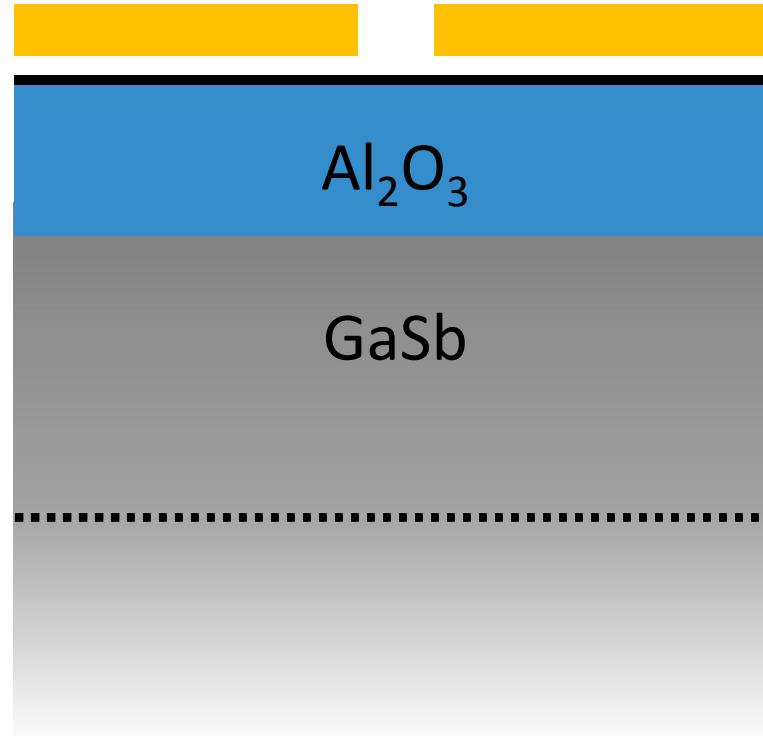


- Tuning occurs only where plasmon is excited and modified with Fermi energy.
- These regions are determined by dielectric cladding layers making them selectable.

Wavelength Selection

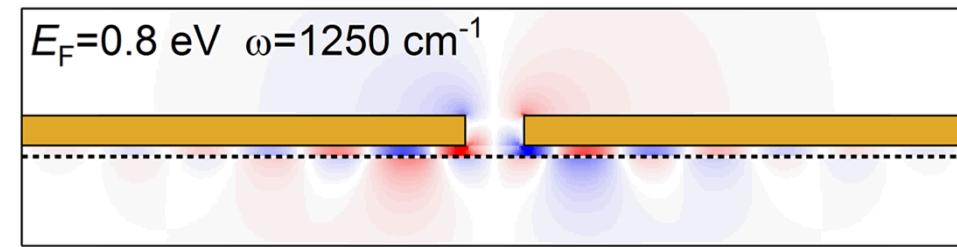
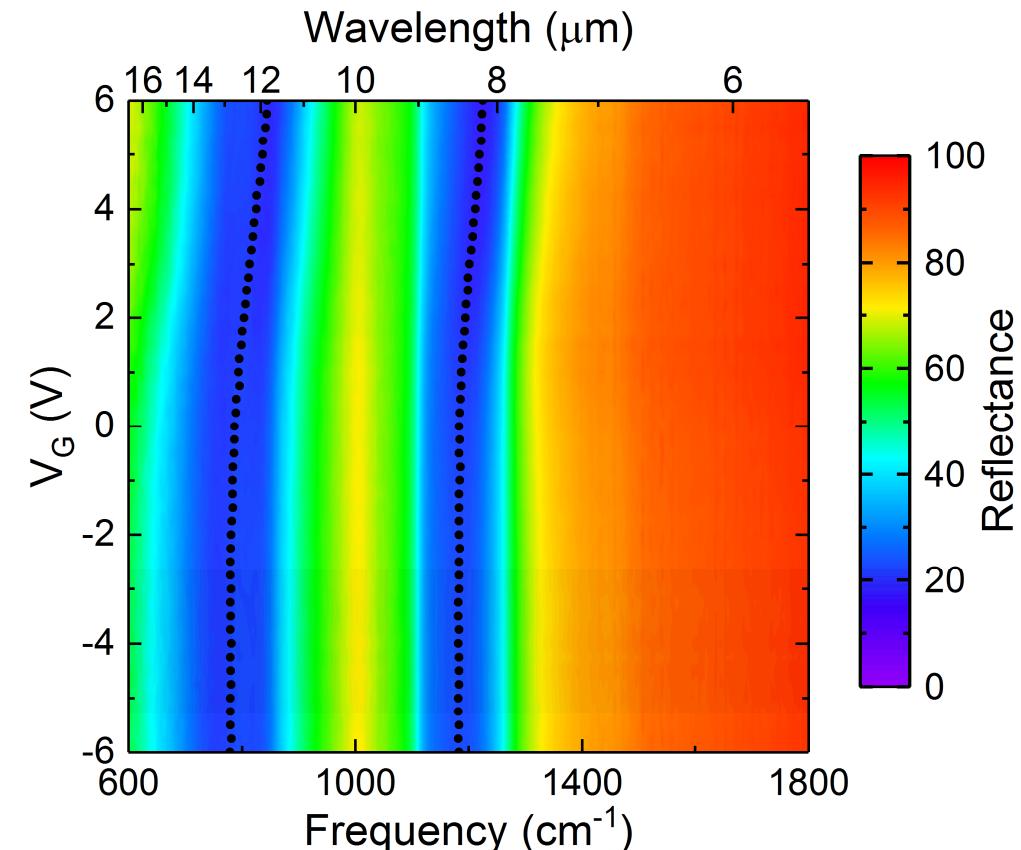
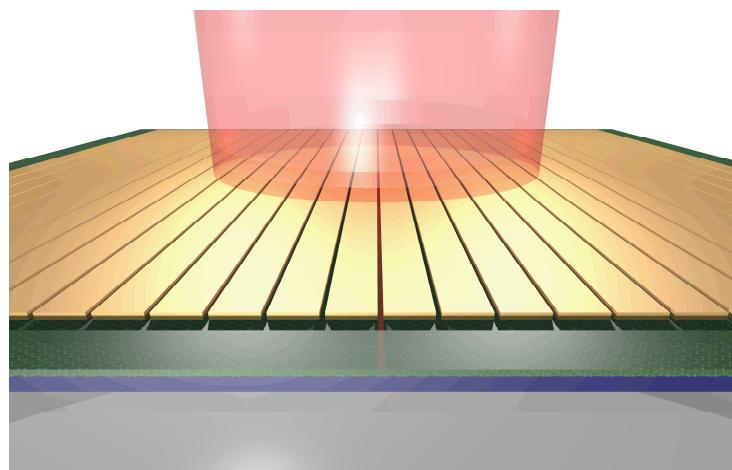


Transmittance-mode Filter

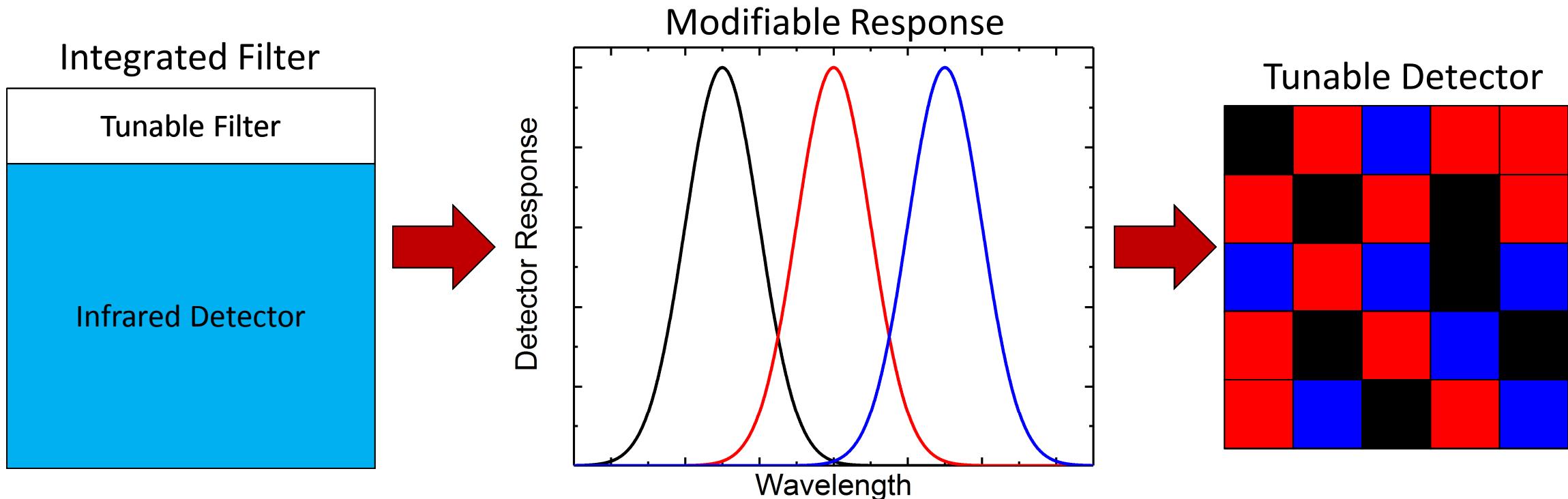


Conclusion

- Demonstrated scalable and tunable graphene-based IR filter.
- Enables modification of response in two bands simultaneously.
- Graphene is continuous and protected for device longevity.
- Mechanisms described here can be used to enable frequency-agile IR sensing.



Outlook



Technical Advances and Issued Patents



Publications

- M.D. Goldflam, I Ruiz, S.W. Howell, J.R. Wendt, M.B. Sinclair, D.W. Peters, T.E. Beechem, "Tunable dual-band graphene-based infrared reflectance filter" in preparation.
- S.W. Howell, I. Ruiz, P. Davids, R. Harrison, S. Smith, M.D. Goldflam, J. Martin, N. Martinez, and T.E. Beechem "Graphene-Insulator-Semiconductor Junction for Hybrid Photodetection Modalities," *Sci. Rep.* Accepted 2017.
- I. Ruiz, M. D. Goldflam, T. E. Beechem, A. E. McDonald, B. L. Draper, and S. W. Howell, "Visibility of dielectrically passivated graphene films" *Opt. Lett.* 42 (14), 2850 (2017).
- Goldflam, M. D.; Campione, S.; Kadlec, E. A.; Hawkins, S. D.; Coon, W. T.; Fortune, T. R.; Parameswaran, S.; Keeler, G. A.; Klem, J. F.; Tauke-Pedretti, A.; Shaner, E. A.; Davids, P. S.; Warne, L. K.; Wendt, J. R.; Kim, J. K.; Peters, D. W., Next-generation infrared focal plane arrays for high-responsivity low-noise applications, 2017 IEEE Aerospace Conference, 4-11 March 2017, 2017; pp 1-7.
- Michael D. Goldflam, Zhe Fei, Isaac Ruiz, Stephen W. Howell, Paul S. Davids, David W. Peters, and Thomas E. Beechem, "Designing graphene absorption in a multispectral plasmon-enhanced infrared detector" *Opt. Express* 25 (11), 12400 (2017).
- F. Léonard, C. D. Spataru, M. Goldflam, D. W. Peters, and T. E. Beechem, "Dynamic Wavelength-Tunable Photodetector Using Subwavelength Graphene Field-Effect Transistors," *Sci. Rep.*, 7, 45873 3 (2017).
- M. D. Goldflam, E. A. Kadlec, B. V. Olson, J. F. Klem, S. D. Hawkins, S. Parameswaran, W. T. Coon, G. A. Keeler, T. R. Fortune, A. Tauke-Pedretti, J. R. Wendt, E. A. Shaner, P. S. Davids, J. K. Kim, D. W. Peters, "Enhanced infrared detectors using resonant structures combined with thin type-II superlattice absorbers," *Appl. Phys. Lett.*, vol. 109, 251103, Dec. 2016.

Technical Advances and Patents

- SD 14080 Hybrid 2D Material/Absorber Structures for Broadband Tunable Detection
- SD 14291 Tunable Optics via Graphene Coupled to Static Resonances
- US 8,452,134 Frequency Selective Infrared Sensors
- US 8,750,653 Infrared Nanoantenna Apparatus and Method for the Manufacture Thereof